

Impedance : From the experimental side



Background on EIS

Experimental set-up

- Which instruments?
- Connection
- Experimental conditions
- Cell

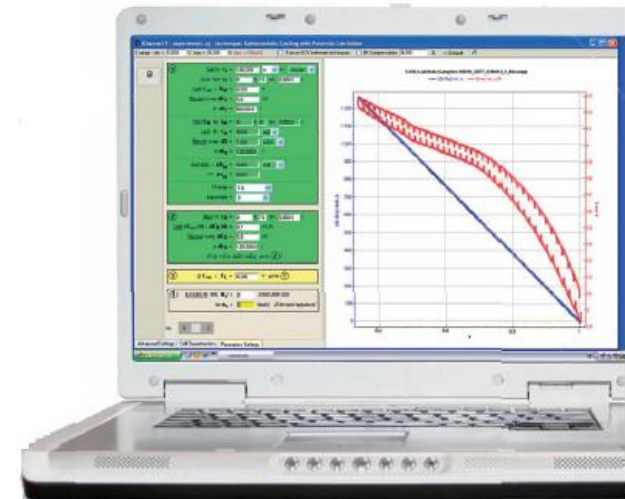


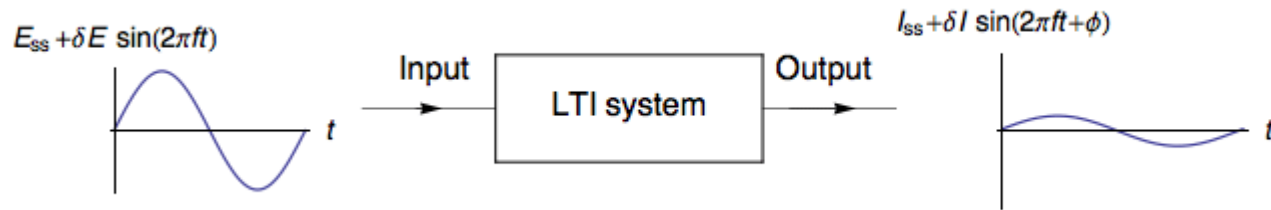
Monitoring software

- Basic parameters (DC or AC voltage/current, frequency,...)
- Advanced parameters (Drift, Multisinus, ...)
- Stack of cell

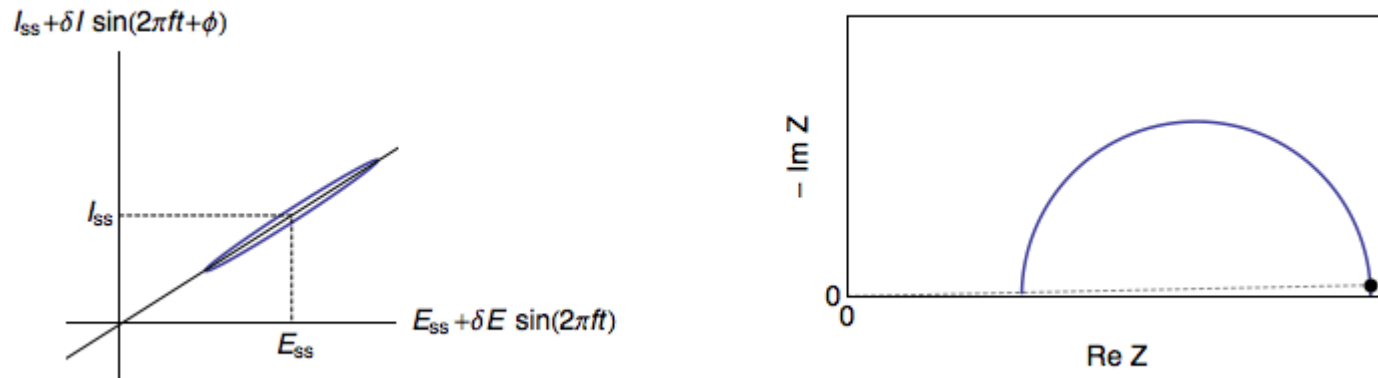
Analysis tools

- Kramers-Kronig
- Zfit
- Mott-Schottky/capacity measurement





Current response has the same frequency with an **amplitude δI** and **phase Φ**
 Perturbation in potential, (it is also possible to perform the same in Galvano)



Increasing the frequency or amplitude  moving away from the steady state I_{ss} vs E curve

$$Z = \mathcal{L}[E(t)] / \mathcal{L}[I(t)]$$

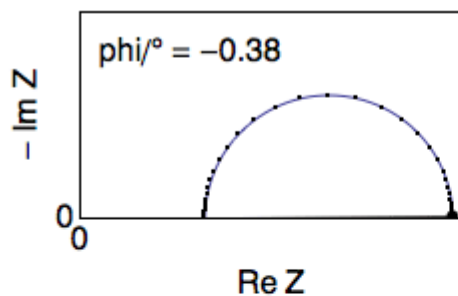
\mathcal{L} : Laplace Transform

The impedance is a complex number:

$$Z = a + j b = \text{Re}(Z) + j \text{Im}(Z) \text{ (with } j^2 = -1)$$

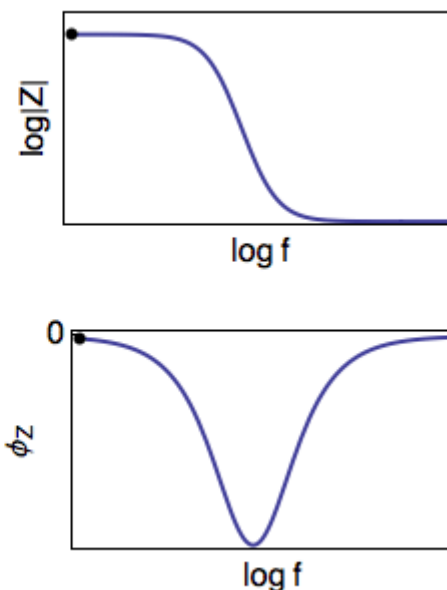
$$Z = \rho(\cos\varphi + j \sin\varphi) \text{ with } \rho \text{ the modulus and } \varphi \text{ the phase}$$

Nyquist diagram



In the Nyquist plot, the impedance for each frequency is plotted in the complex plane $-\text{Im}(Z)$ vs $\text{Re}(Z)$.

Bode diagram



In the Bode Plot, the modulus and the phase of the impedance are plotted against the frequency of the modulation.

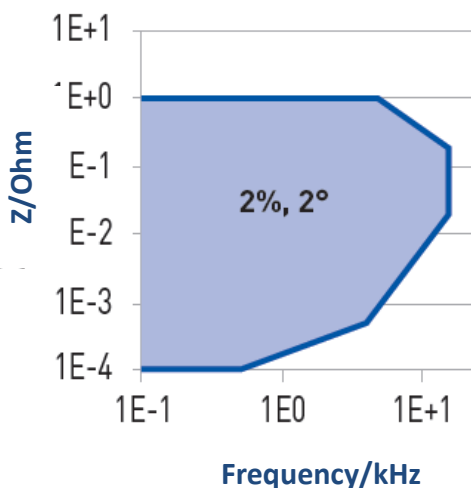
How to optimize the setup?

- Which instruments for my measurements?
- Connection
- Experimental conditions
- Cell

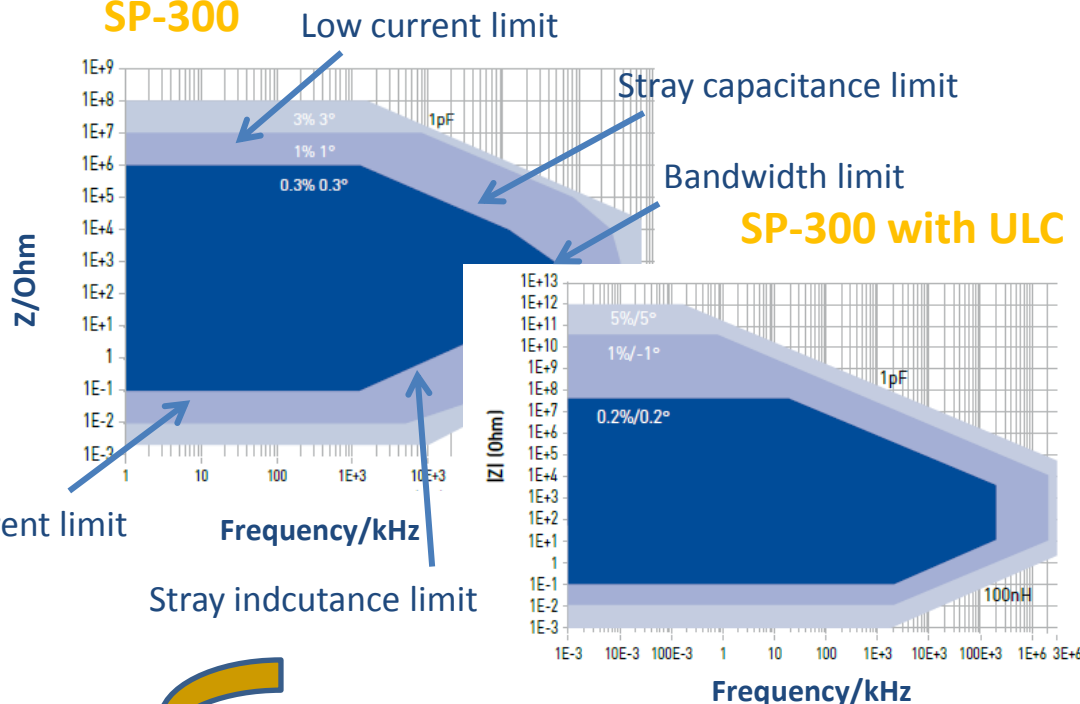
Select the appropriate instrument ...

...in the optimized configuration *i.e.* low current option, high current option...

HCP-803



SP-300



SP-300 with ULC

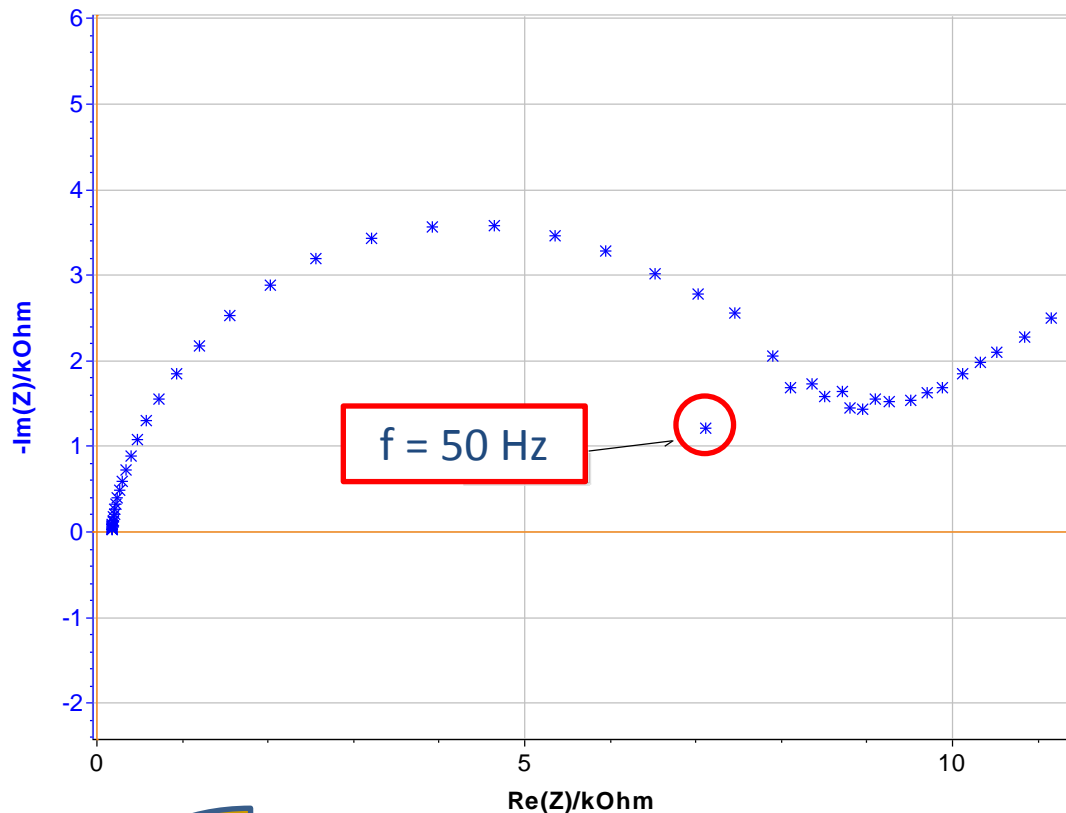


For a system with low impedance (such as battery, supercapacitor), select a potentiostat with a current booster.



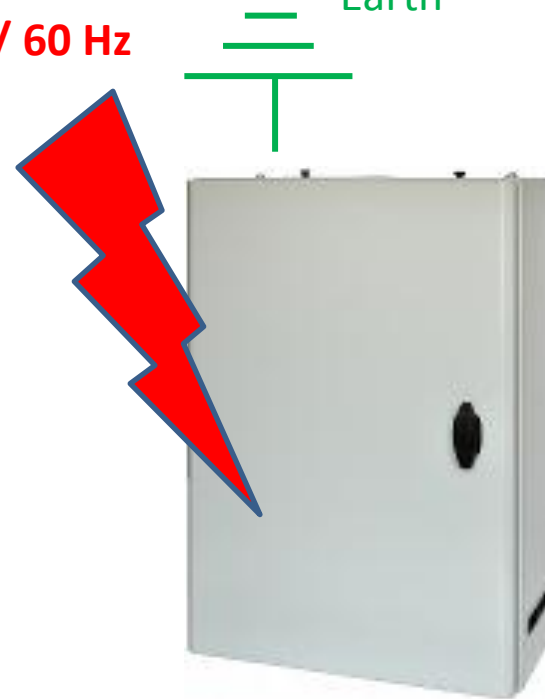
For a system with high impedance (such as a coating), SP-300 with ULC can be of interest

Protect the cell from any external disturbance



50 / 60 Hz

Earth



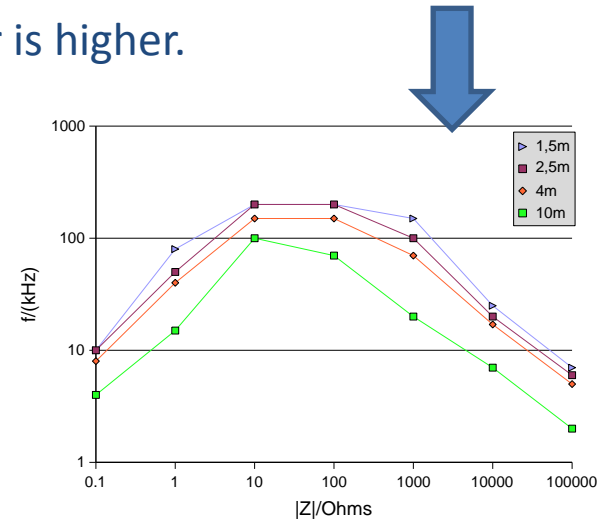
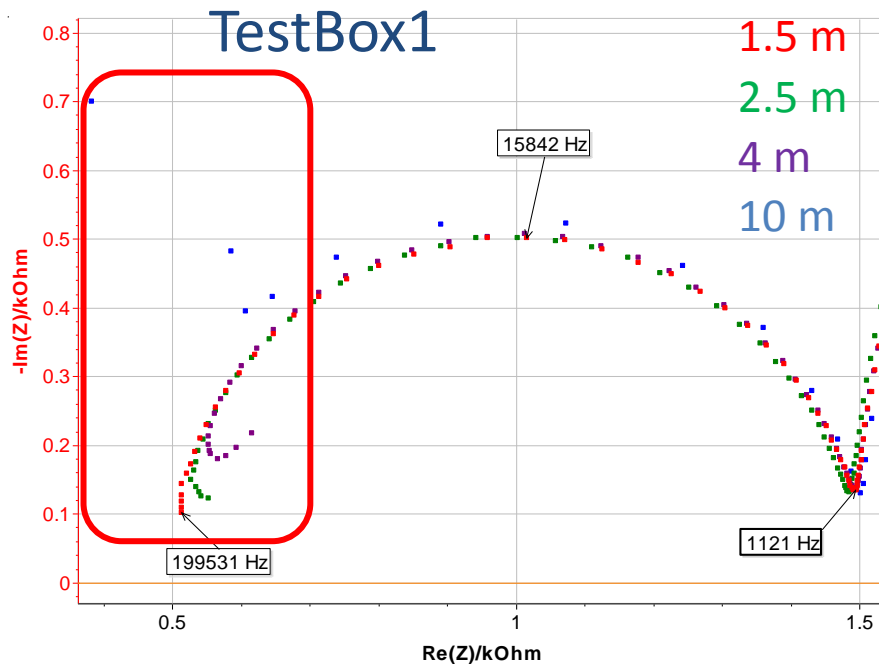
Faraday cage



Use a Faraday cage connected to the earth of the potentiostat
Especially for low current measurements.

Why?

- Because this affects the bandwidth of the potentiostat.
Error is higher.



- Capacity of the extra cable is added.
Specifications given are the specifications at the end of the leads of the standard cable.

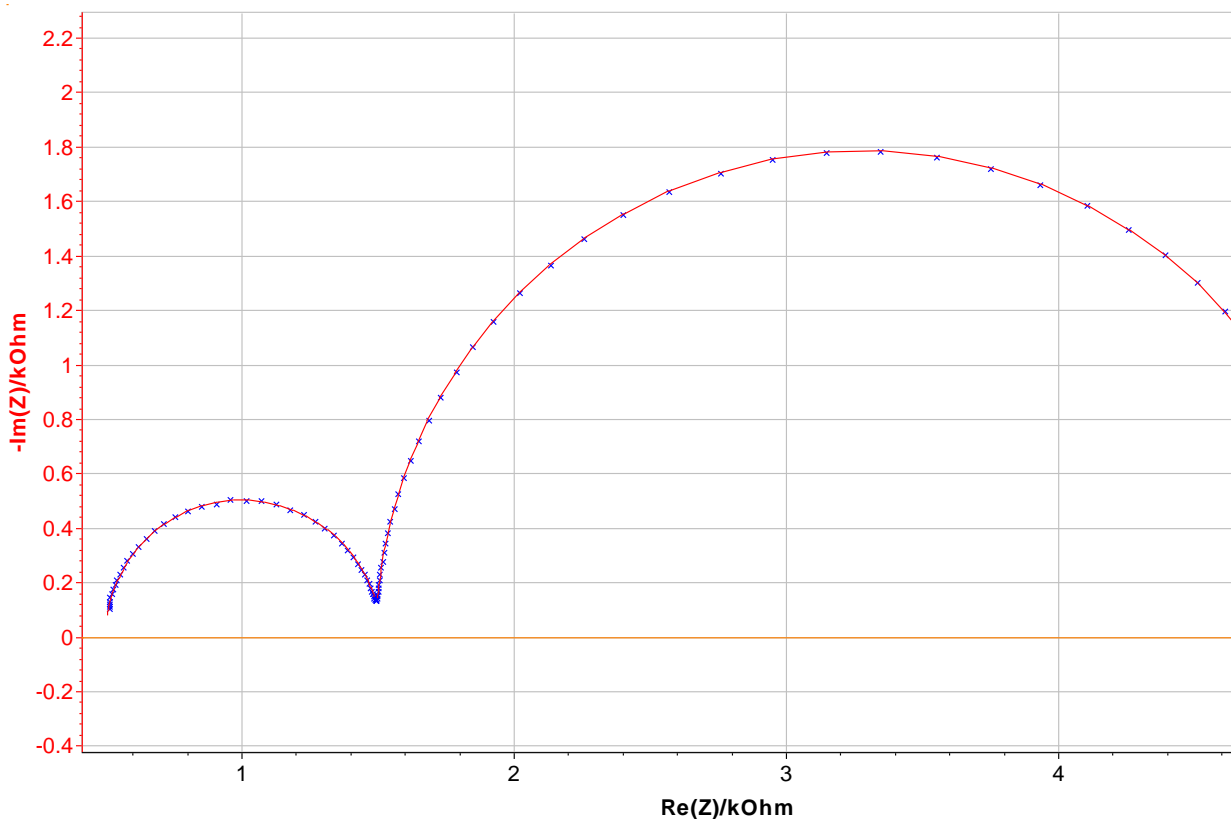


Avoid extended cable
Affect the EIS measurement especially at high frequencies

It is possible to evaluate the error thanks to EC-Lab:

1. Fit the resulting EIS data of 1.5 m
2. Use these fitted values as reference
3. Compare these reference values with the data obtained with 10 m cable (Plot the error data vs. frequency, for the 1.5 m cable and for the 10 m cable)

1- Fit of the EIS data obtained with 1.5 m cable



It is even clearer in the Bode plot

Z Fit

Selection: Results

Equivalent circuit: R1+C2/R2+C3/R3

param.	sel.	sign	value	unit	dev.
R1	<input checked="" type="checkbox"/>	+/-	497.3	Ohm	0.101 5
C2	<input checked="" type="checkbox"/>	+/-	9.468e-9	F	12.5e-12
R2	<input checked="" type="checkbox"/>	+/-	998.9	Ohm	0.229 9
C3	<input checked="" type="checkbox"/>	+/-	2.146e-6	F	0.888e-9
R3	<input checked="" type="checkbox"/>	+/-	3 572	Ohm	0.279 2

Calculate

Fit

Select: all cycle(s)

Method: Randomize + Simplex

Randomize: first cycle only

Stop randomize on: 10000 iterations

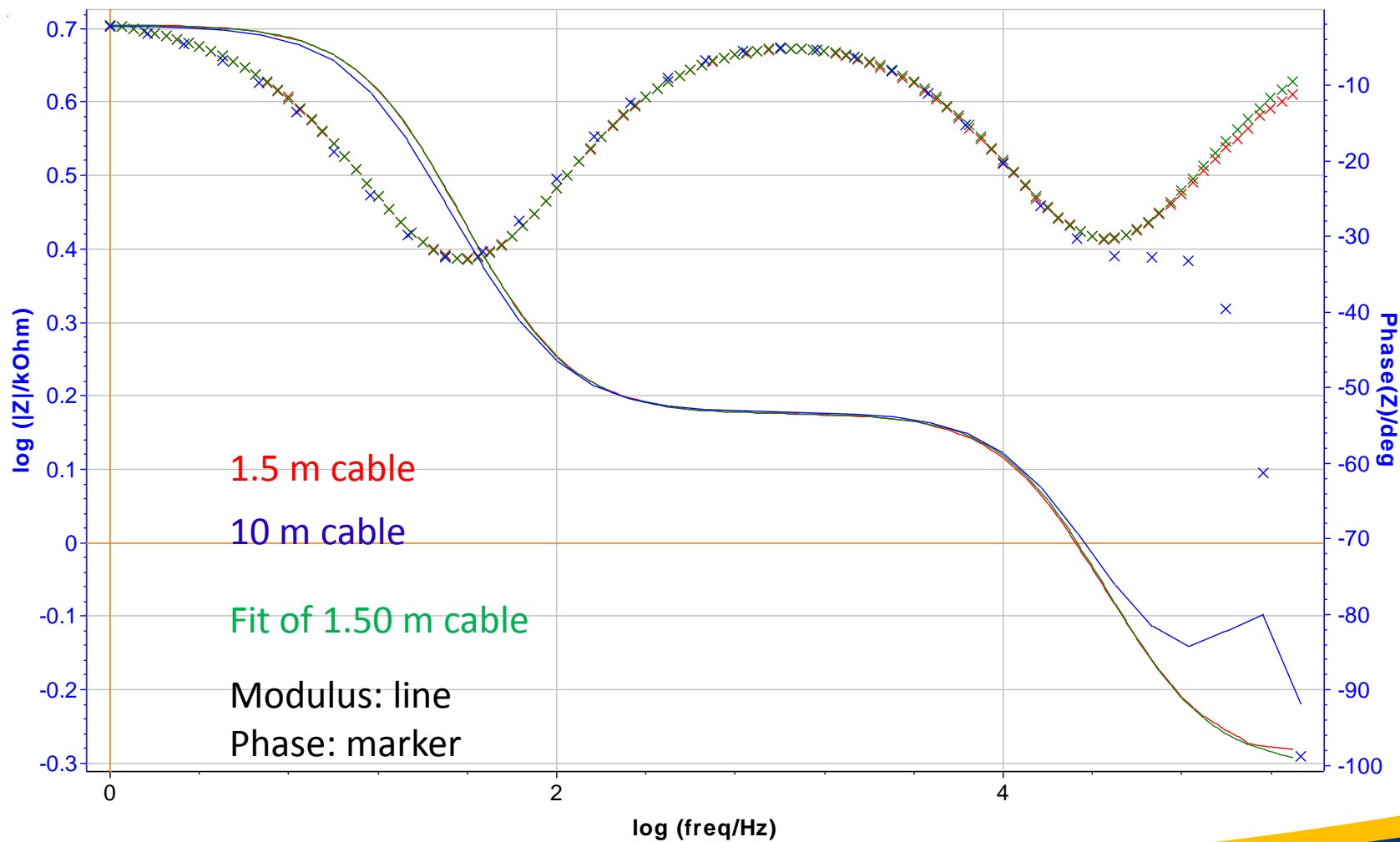
Stop fit on: 5000 iterations

Weight:

χ^2 : 7.115e-3 χ^2/\sqrt{N} : 8.154e-3

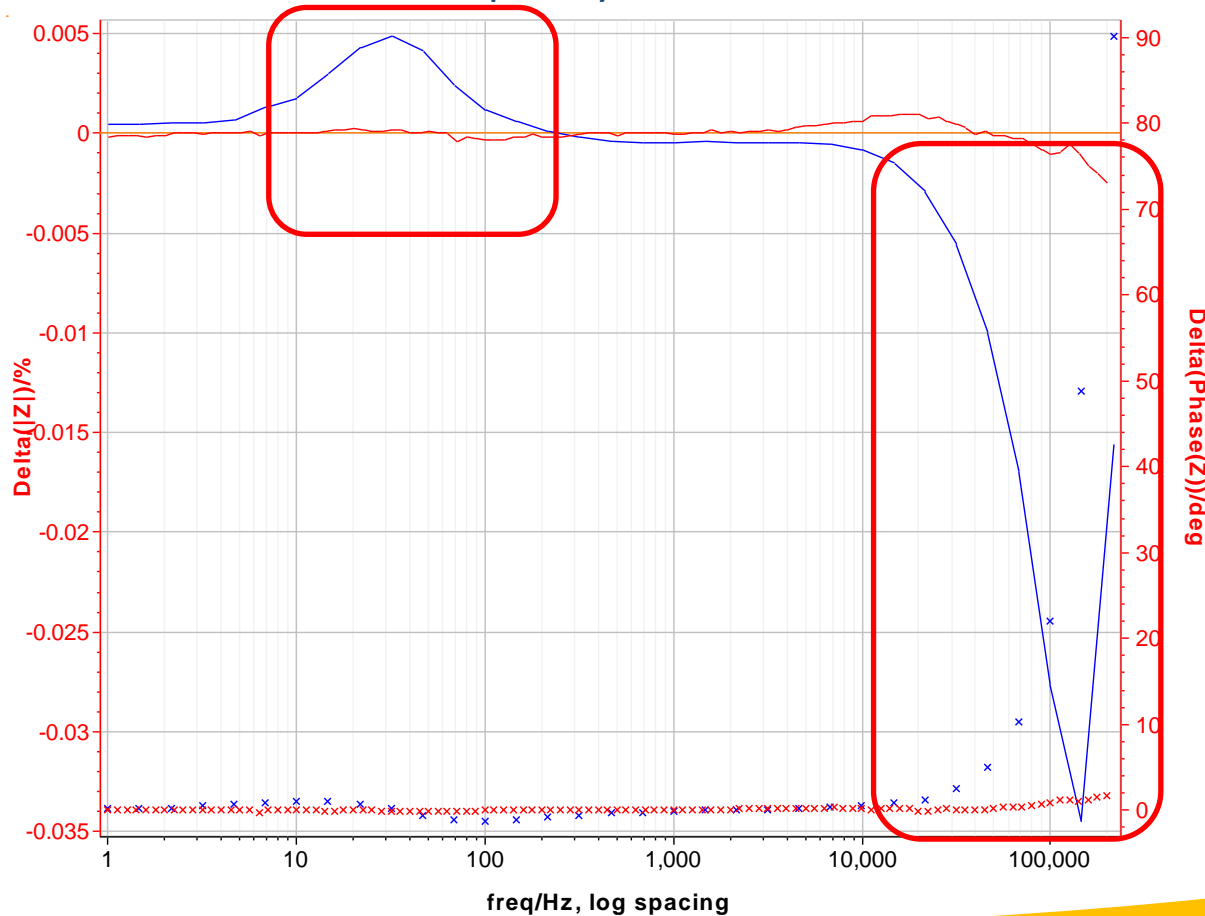
Iterations: 5000 (Simplex) Cycle: xxxx

Minimize PseudoC Copy Save Close



2. Use these fitted values as reference

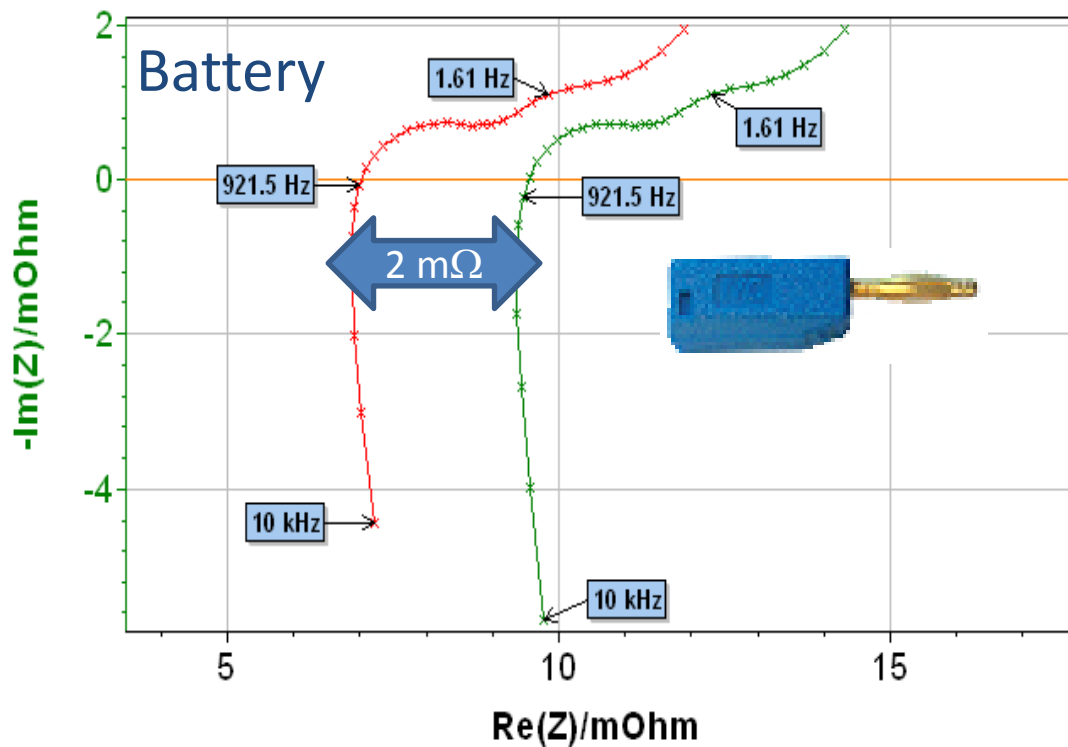
3. Compare these reference values with the data obtained with 10 m cable
 (Plot the error data vs. frequency, for the 1.5 m cable and for the 10 m cable)



1.5 m cable

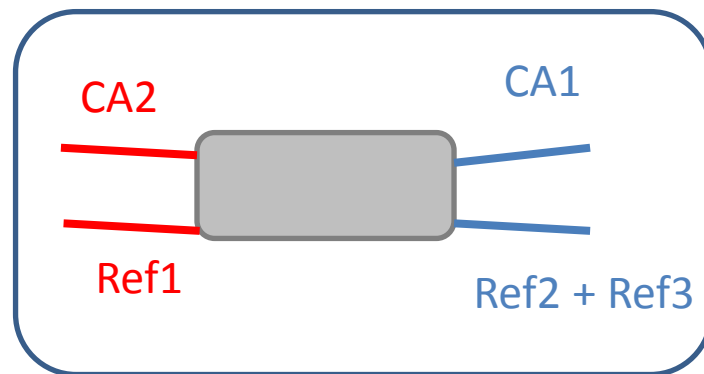
10 m cable

Modulus: line
 Phase: marker



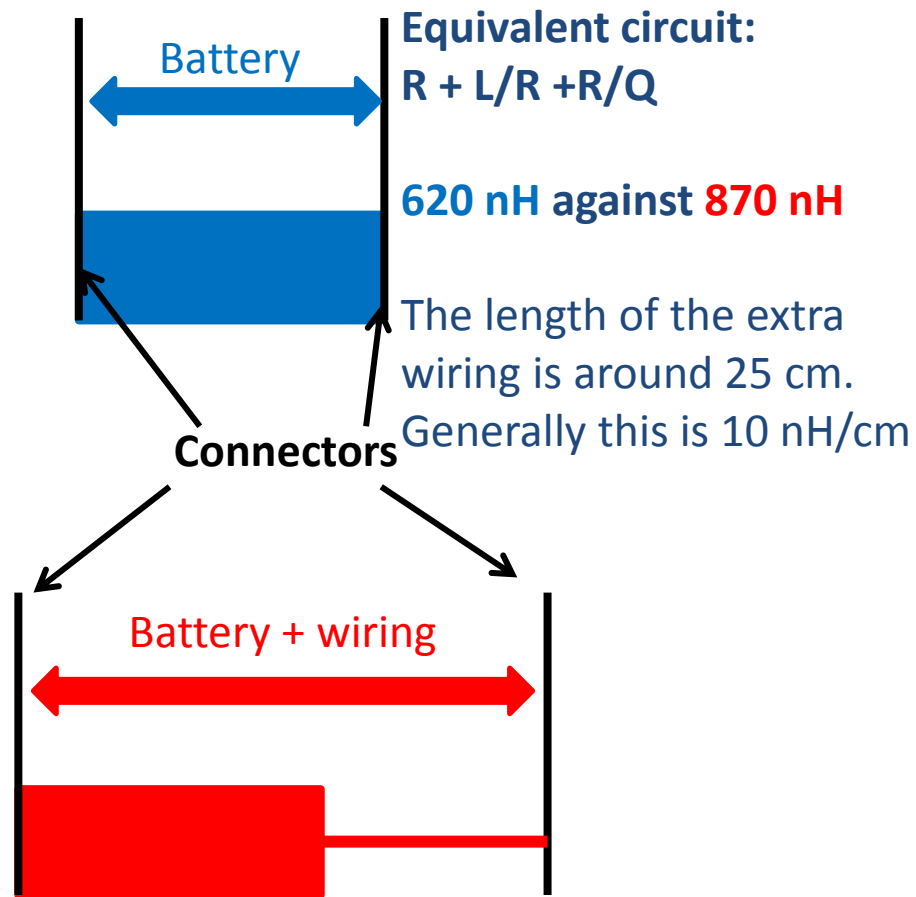
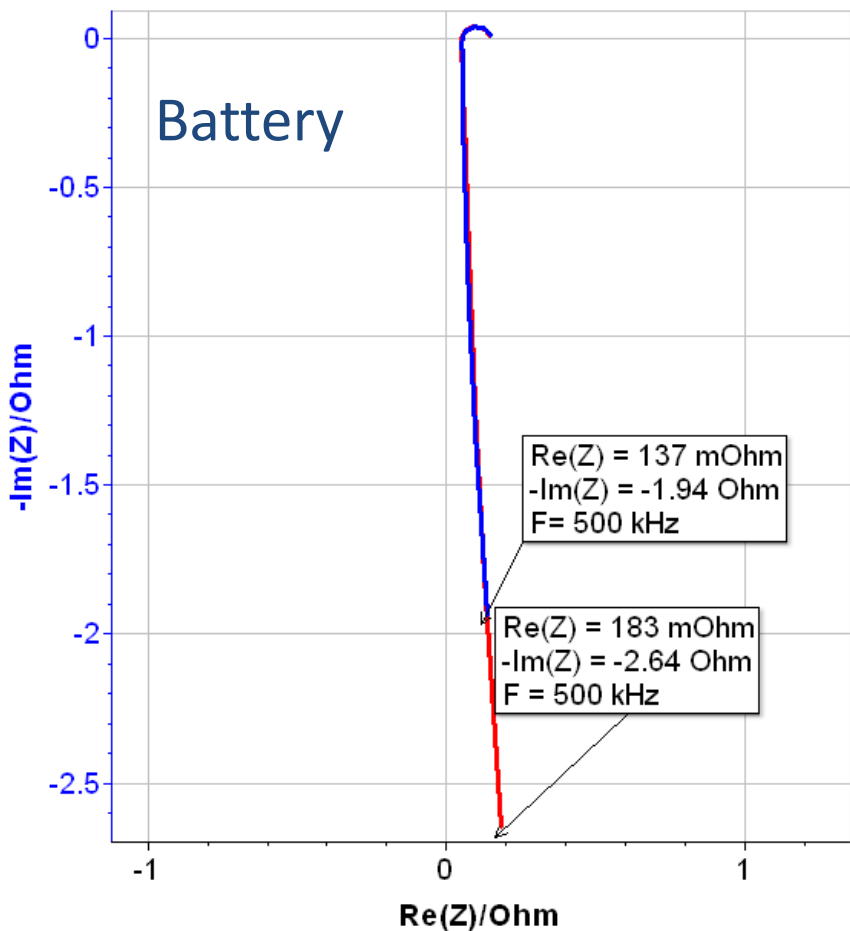
Contact resistance is no more negligible for low impedance system.

In that case, 4-point measurements has to be considered:



Affects the measurement at low level of impedance.
This is particularly relevant for battery, supercapacitor investigations...

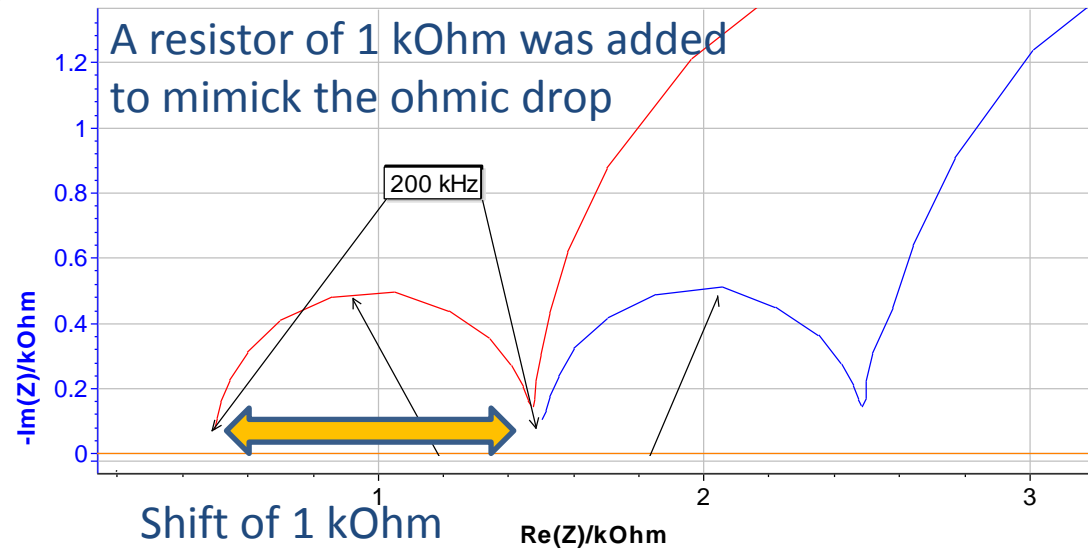
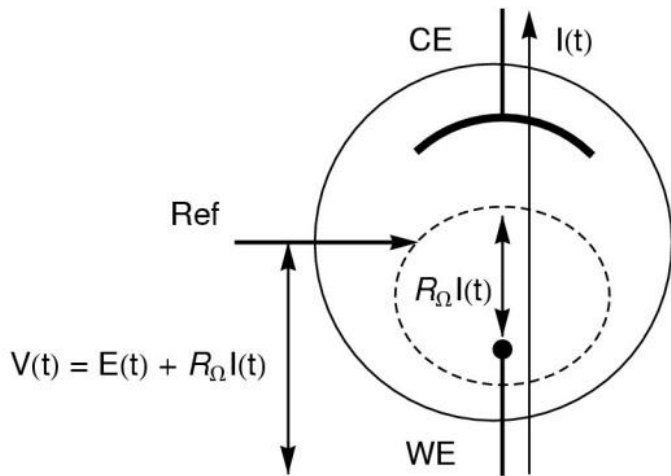
CONNECTION (inductive effect)



Affects the measurement at low level of impedance.
 This is particularly relevant for battery, supercapacitor investigations...

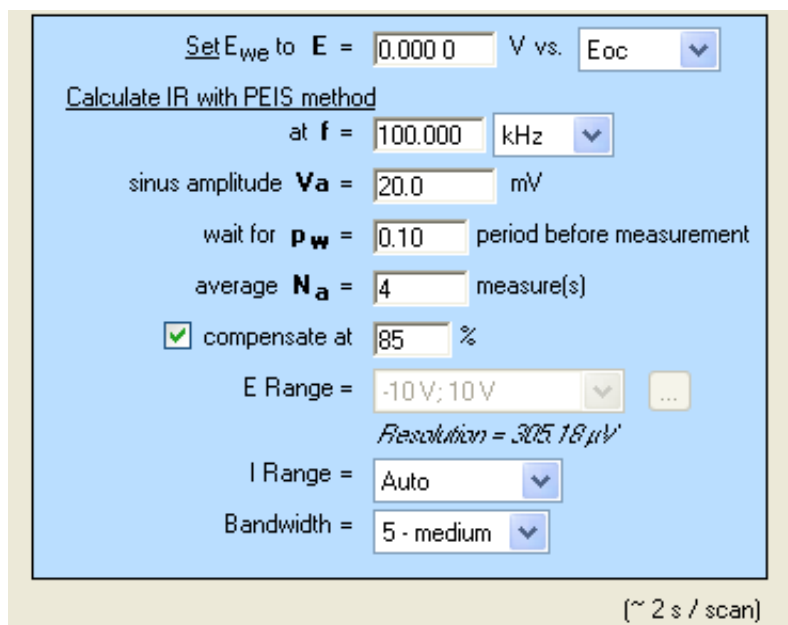
Reduce ohmic drop of the cell by:

- decreasing the distance between RE and WE
- changing the Vycor glass of the RE
- ...

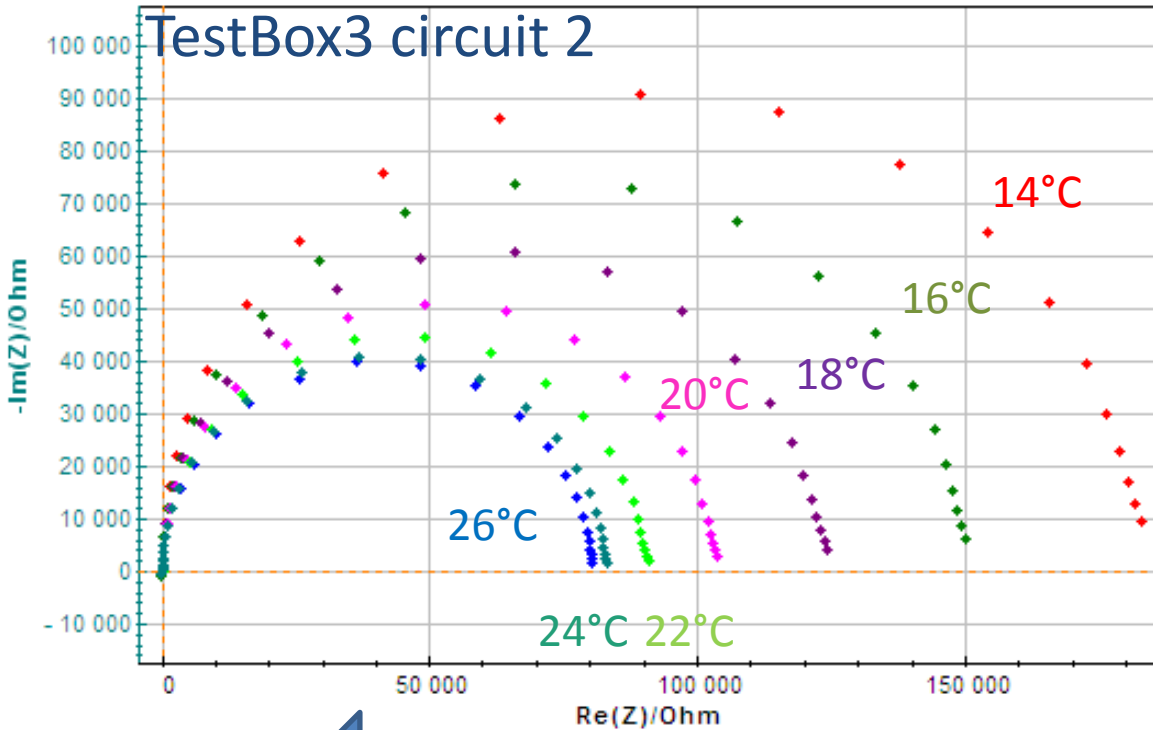


Affects the measurement of low impedance system at high frequency (battery, supercapa, ...)

Determine/compensate the ohmic drop resistance thanks to ZIR technique (measure the $Re(Z)$ at one frequency).



Note that it is not possible to compensate ohmic drop for EIS measurement.

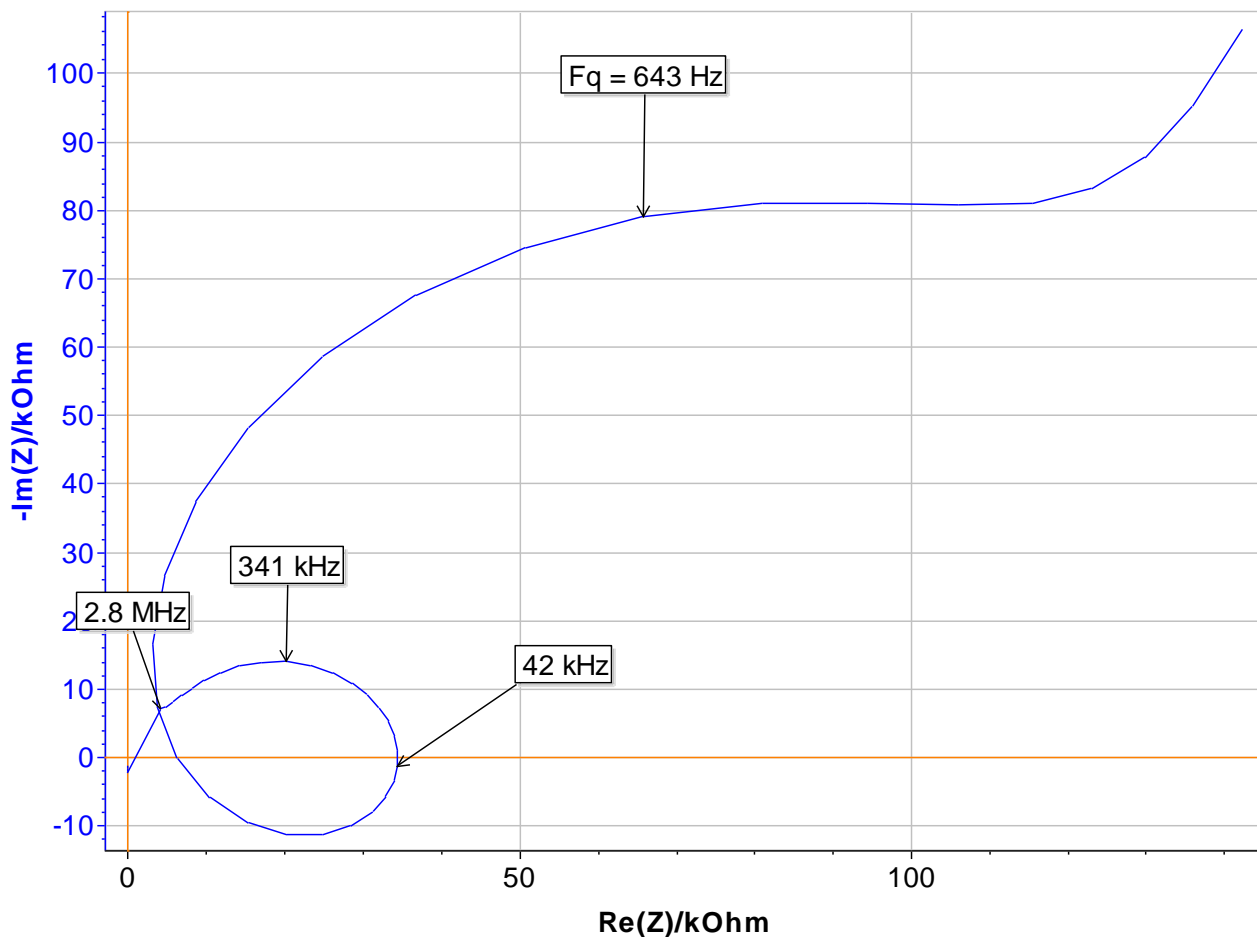


For example, if one experiment is performed during the night and another one during the day, a difference between both spectra can be observed.

R decreases when Temp increases

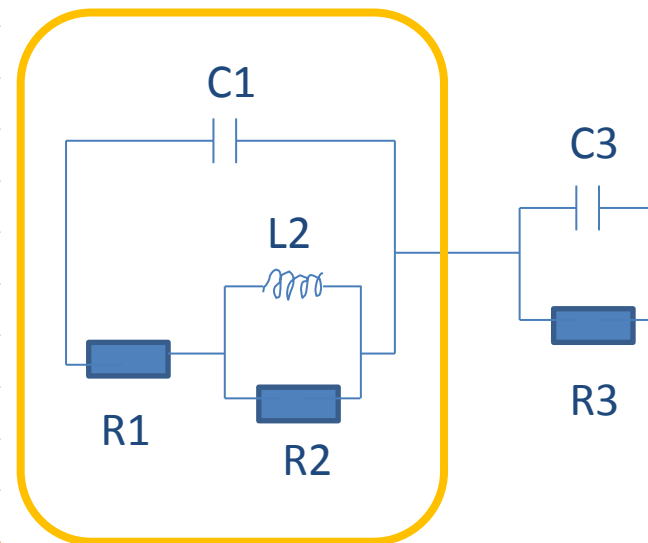
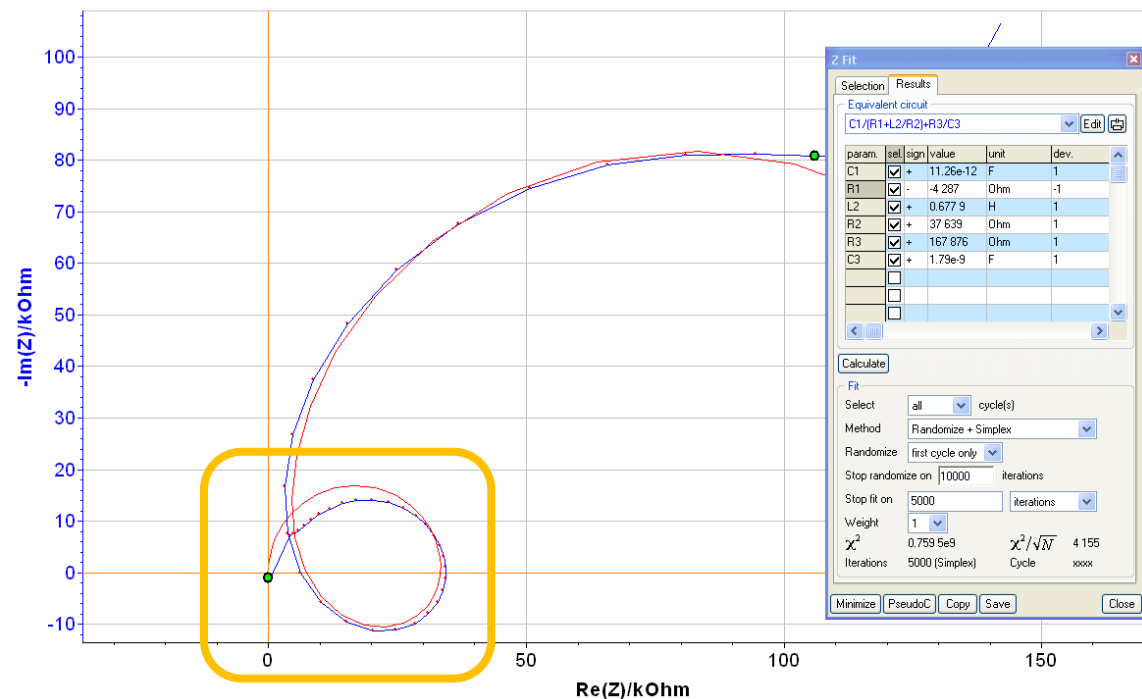


Control of temperature of the cell may be required.



What's that?

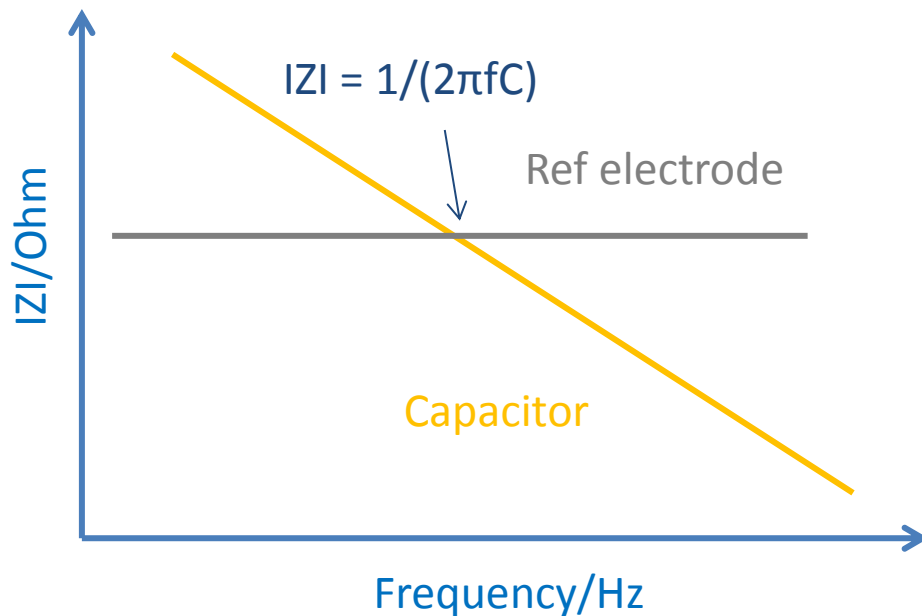
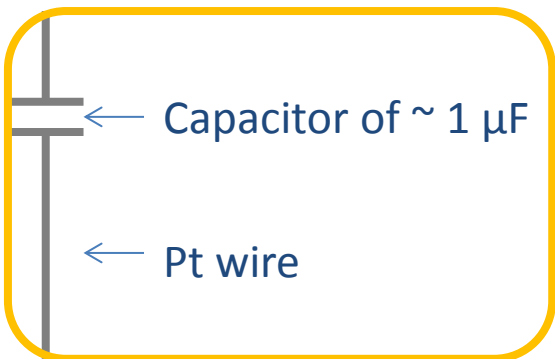
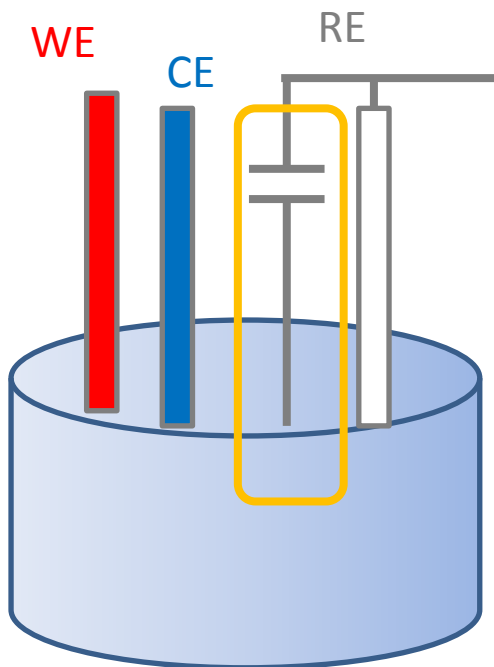
Only artifact due to reference electrode impedance not negligible at high frequencies



ZRef

This is due to the Ref Electrode

A solution:



At high frequency the impedance of the capacitor is negligible

How to optimize the settings in EC-Lab[®] software?

- Which techniques in EC-Lab[®]/EC-Lab[®] Express
- Basic parameters (DC or AC voltage/current, frequency,...)
- Advanced parameters (Drift, Multisinus, ...)
- Stack of cell

Insert Techniques

- Electrochemical Techniques
 - Voltamperometric Techniques
 - Impedance Spectroscopy
 - Galvano Electrochemical Impedance Spectroscopy - GEIS
 - Potential Electrochemical Impedance Spectroscopy - PEIS
 - Staircase Galvano Electrochemical Impedance Spectroscopy - SGEIS
 - Staircase Potential Electrochemical Impedance Spectroscopy (Mott-Schottky) - SPEIS
 - Potential Electrochemical Impedance Spectroscopy Wait - PEISW
 - Pulsed Techniques

PEIS: control of the perturbation in voltage

GEIS: control of the perturbation in current

SPEIS: PEIS at several DC voltage bias

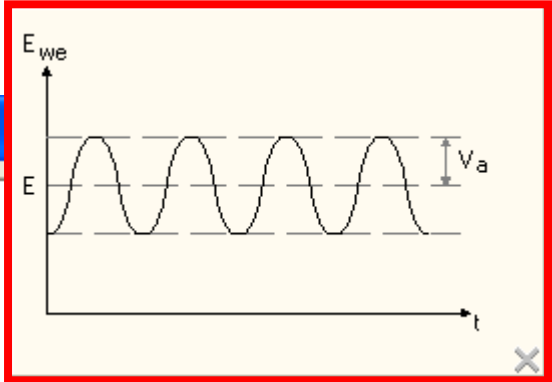
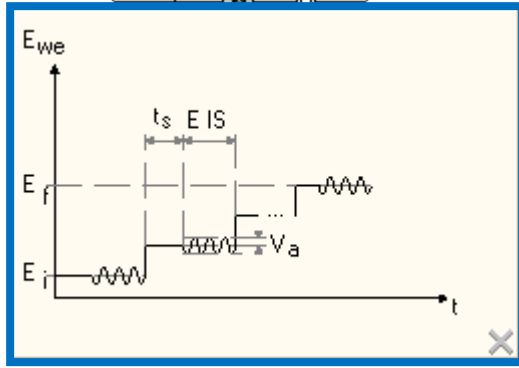
SGEIS: GEIS at several DC current bias

PEISW: PEIS at one frequency versus time

Insert Technique: Before After

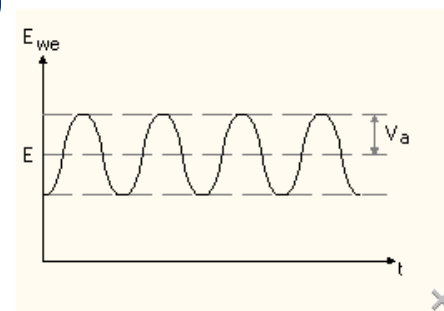
Load from default: Advanced setting External devices Cell characteristics

Custom Applications:

$$E(t) = E_{DC} + V_a \sin(2\pi f t)$$

$$I(t) = I_{DC} + I_a \sin(2\pi f t)$$



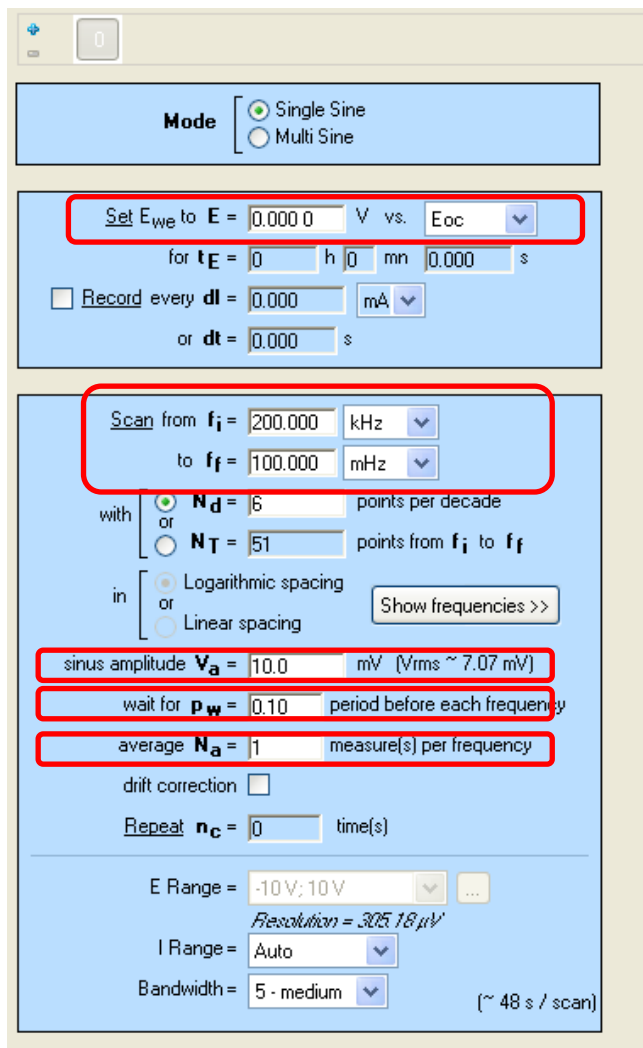
E_{DC}/I_{DC} : defines the bias level (bias current for galvanostatic or bias voltage for potentiostatic) DC level

f_i/f_f : initial /final frequency

V_a/I_a : defines the amplitude of AC perturbation (be careful, it is an amplitude and not peak-to-peak or RMS amplitude)

P_w : offers the possibility to add a delay before the measurement at each frequency. This delay is defined as a part of the period. So the delay is longer for low frequencies.

N_a : repeats N_a measure(s) and average the values for each frequency.



Mode: Single Sine Multi Sine

Set E_{we} to $E = 0.0000$ V vs. E_{oc}

for $t_E = 0$ h 0 mn 0.000 s

Record every $dI = 0.000$ mA

or $dt = 0.000$ s

Scan from $f_i = 200.000$ kHz to $f_f = 100.000$ mHz

with $N_d = 6$ points per decade or $N_T = 51$ points from f_i to f_f

in Logarithmic spacing or Linear spacing

sinus amplitude $V_a = 10.0$ mV ($V_{rms} \sim 7.07$ mV)

wait for $p_w = 0.10$ period before each frequency

average $N_a = 1$ measure(s) per frequency

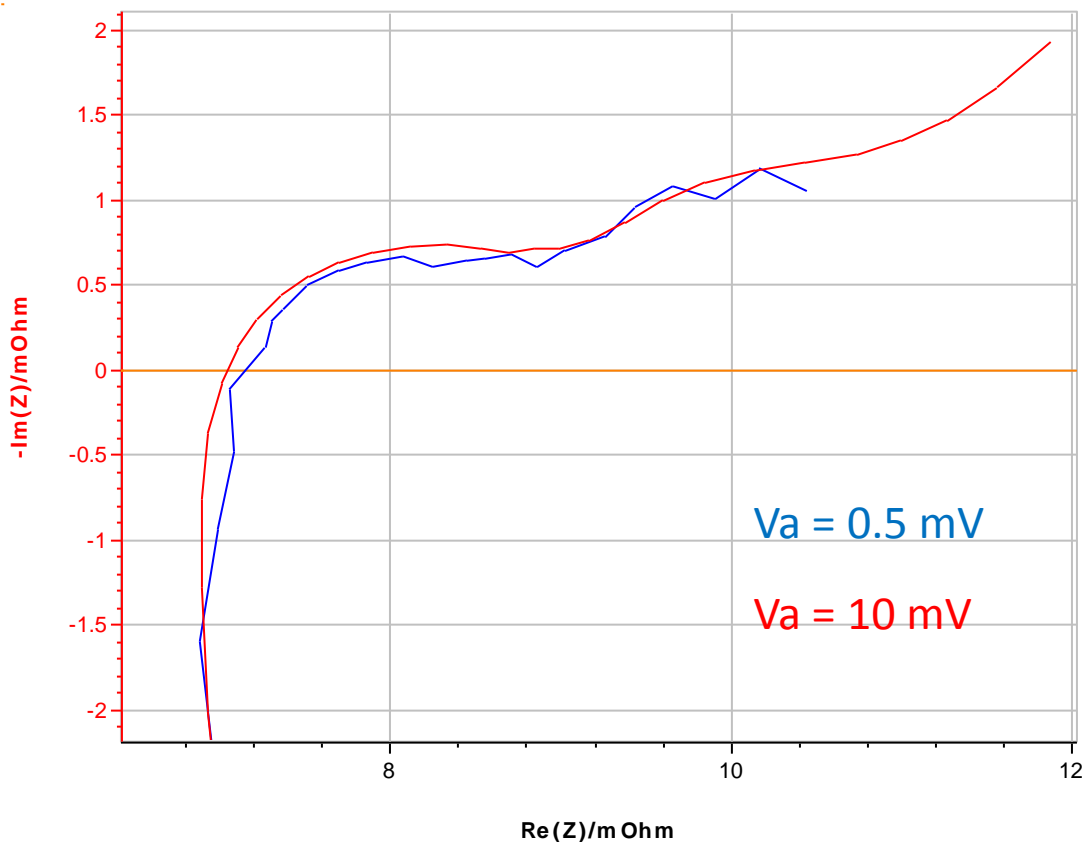
drift correction

Repeat $n_c = 0$ time(s)

E Range = $-10V; 10V$ Resolution = $305.18 \mu V$

I Range = Auto

Bandwidth = 5 - medium (~ 48 s / scan)

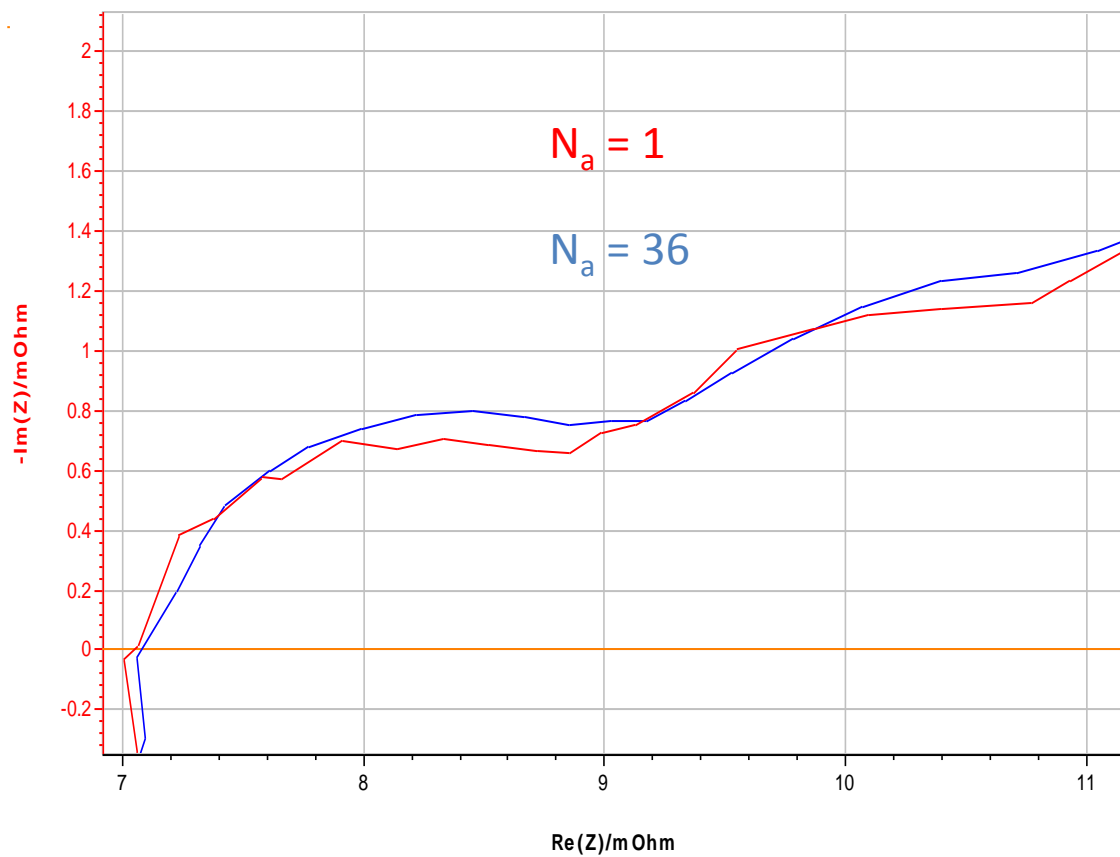


The resulting current and potential value should be in agreement with the accuracy of the instrument.



Amplitude of the controlled signal (V_a or I_a) should be:

- high enough to induce a significant amplitude of the response
- Small enough to keep the linear behavior of the cell.

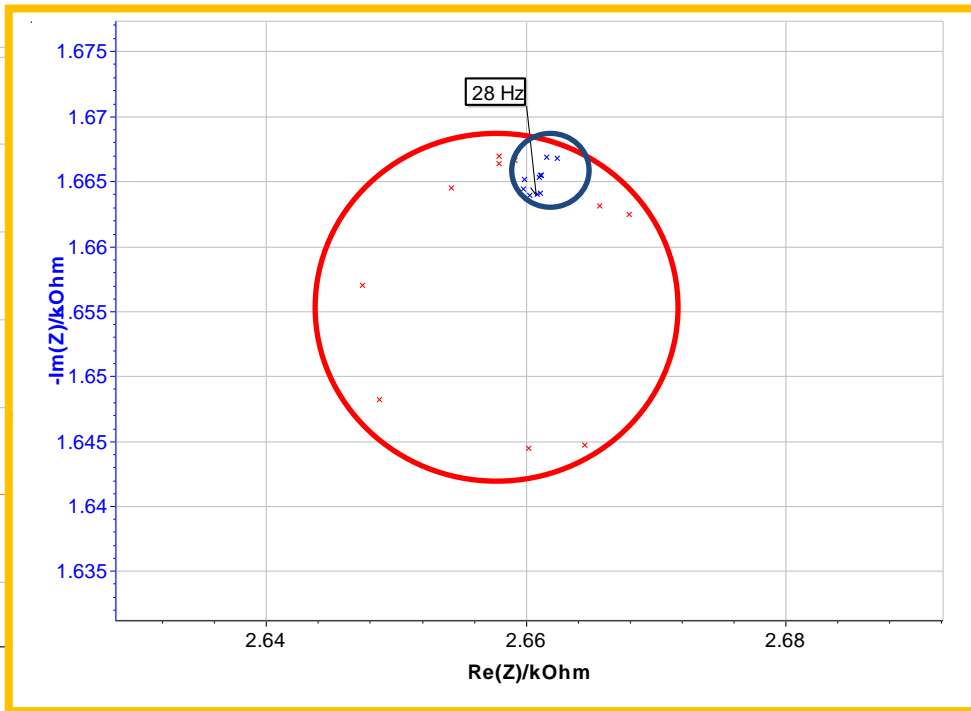
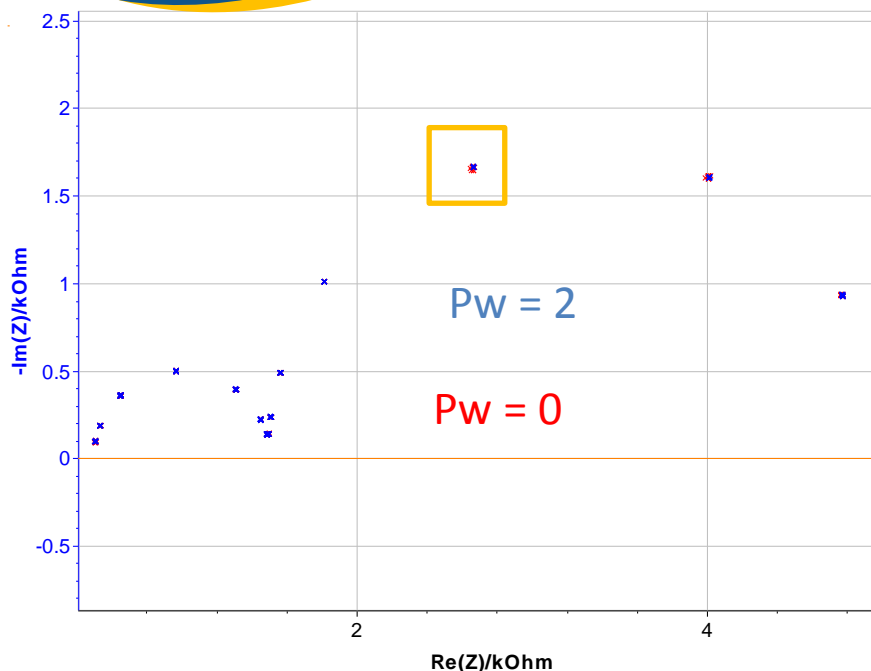


Curve with $N_a = 36$ is less noisy than the one with $N_a = 1$.

Noise is divided by the $N^{1/2}$



This average process smoothes the random error of the measurement.



Curve with $P_w = 2$ is less scattered than the one with $P_w = 0$.

This result means that it is possible to slightly compensate a noisy shape of an EIS diagram just by increasing the P_w value and without disturbing the cell much.

Memory effect of the system



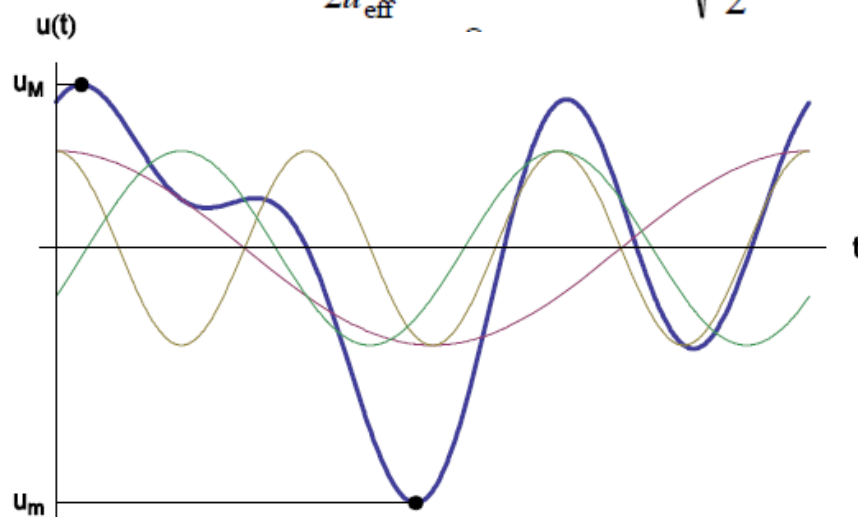
Important to activate this option when there is a big gap between two frequencies .

Sum of sinus

$$u(t) = A \sum_{k=1}^N \cos(2\pi f_k t + \Phi_k) \text{ with the phase } \Phi_k = \Phi_1 - 2\pi \sum_{n=1}^{k-1} \frac{(k-n)}{N}$$

Minimize the crest factor (avoid too large excitation, this might result in a measurement in the non-linear response domain of the electrochemical cell):

$$Cr(u) = \frac{u_M - u_m}{2u_{\text{eff}}} \text{ with } u_{\text{eff}} = A \sqrt{\frac{N}{2}}$$



Advantages:

- Reduce time of the measurement (activated below 10 Hz)
- Avoid drifts for non-steady state system on measurement at low frequency

Mode Single Sine Multi Sine

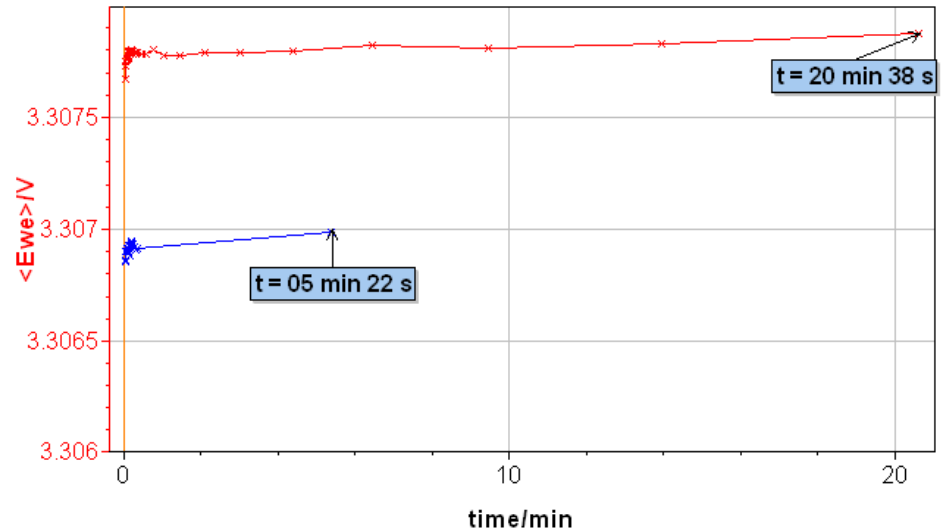
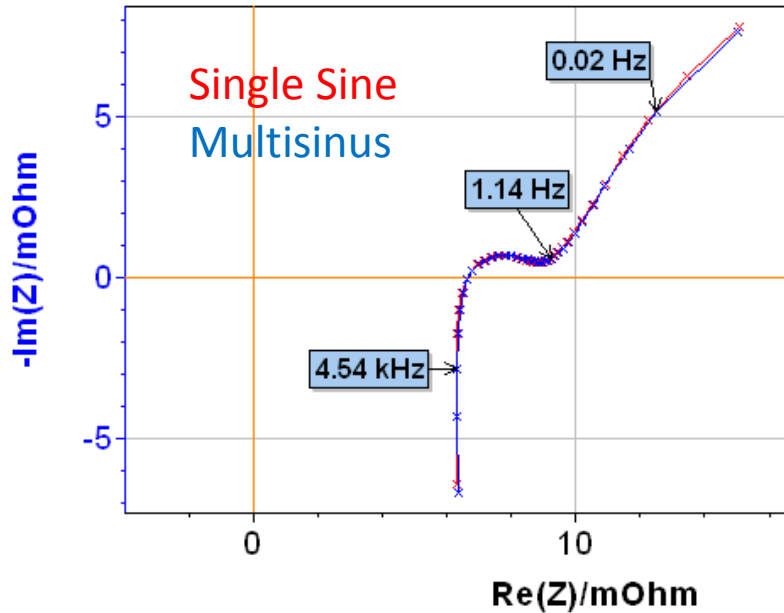
Set E_{we} to $E = 0.0000$ V vs. E_{oc}
 for $t_E = 0$ h 0 mn 0.000 s
 Record every $dl = 0.000$ mA
 or $dt = 0.000$ s

Scan from $f_i = 200.000$ kHz
 to $f_f = 100.000$ mHz
 with $N_d = 6$ points per decade
 or $N_T = 51$ points from f_i to f_f
 in Logarithmic spacing Linear spacing

 sinus amplitude $V_a = 10.0$ mV ($V_{rms} \sim 7.07$ mV)
 wait for $p_w = 0.10$ period before each frequency
 average $N_a = 1$ measure(s) per frequency
 drift correction
 Repeat $n_c = 0$ time(s)
 E Range = -10 V; 10 V
 Resolution = $305.18 \mu V$
 I Range = Auto
 Bandwidth = 5 - medium
 (~ 25 s / scan)

Same result....

....for less time (5 mn instead of 20 mn)

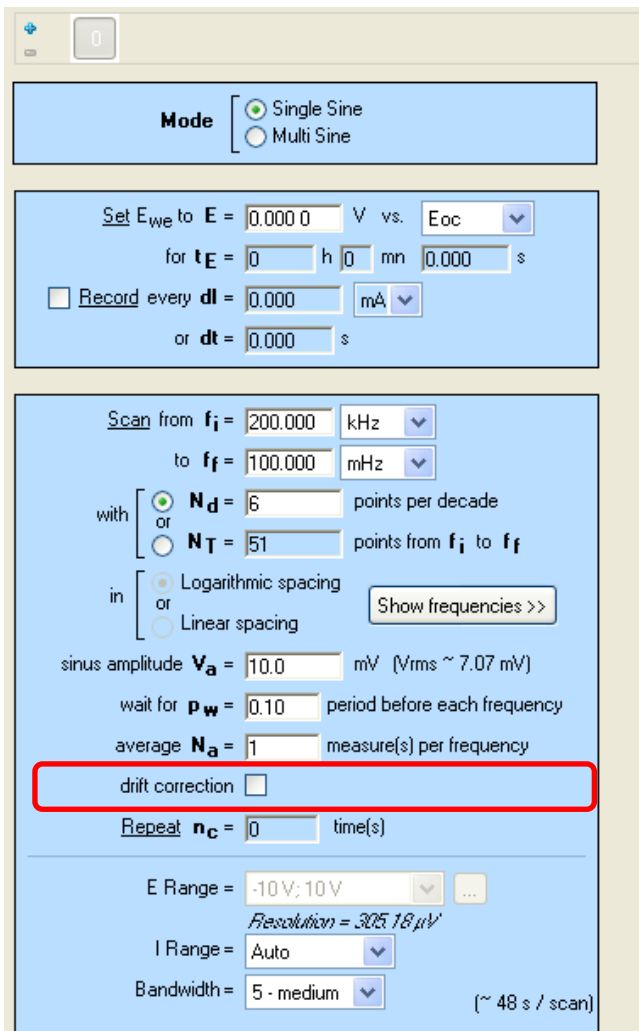


This is especially important for EIS at low frequency (such as battery)

Theoretically, an EIS experiment has to be performed only on the system at its steady state but for slow system such as battery, this is almost never the case, so this option allows the user to perform EIS experiment on a system which is not yet in its steady state.

This is a patented process.

Note: Duration of the experiment will be twice longer.



Mode: Single Sine, Multi Sine

Set E_{we} to $E = 0.0000$ V vs. E_{oc}

for $t_E = 0$ h 0 mn 0.000 s

Record every $dI = 0.000$ mA

or $dt = 0.000$ s

Scan from $f_i = 200.000$ kHz to $f_f = 100.000$ mHz

with $N_d = 6$ points per decade or $N_T = 51$ points from f_i to f_f

in Logarithmic spacing or Linear spacing [Show frequencies >>](#)

sinus amplitude $V_a = 10.0$ mV ($V_{rms} \sim 7.07$ mV)

wait for $p_w = 0.10$ period before each frequency

average $N_a = 1$ measure(s) per frequency

drift correction

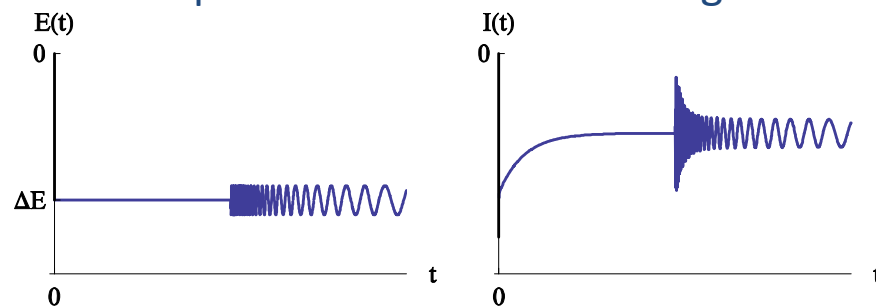
Repeat $n_c = 0$ time(s)

E Range = -10 V; 10 V Resolution = $305.18 \mu V$

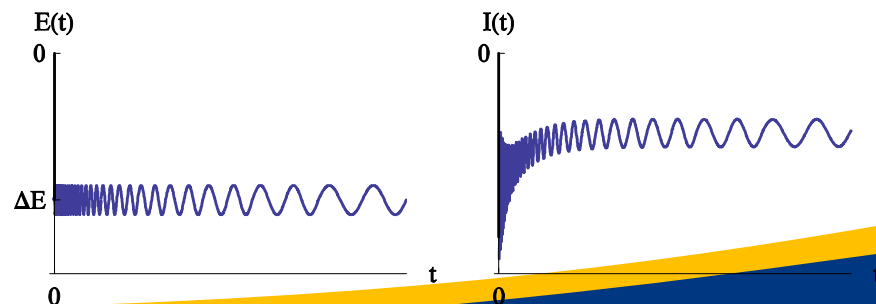
I Range = Auto

Bandwidth = 5 - medium (~ 48 s / scan)

In its steady-state

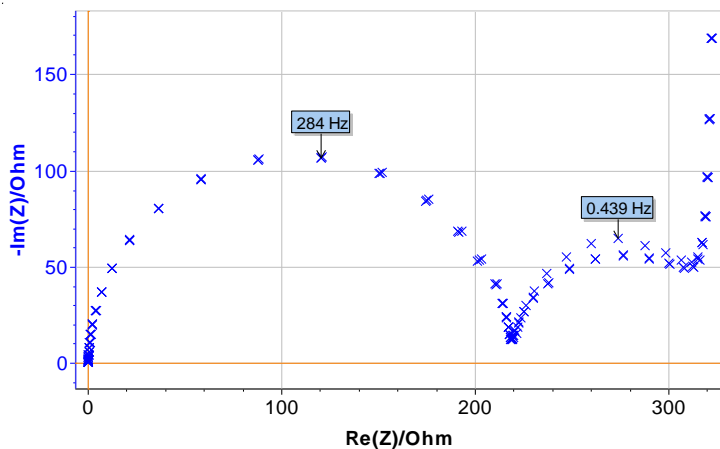


Not in its steady-state

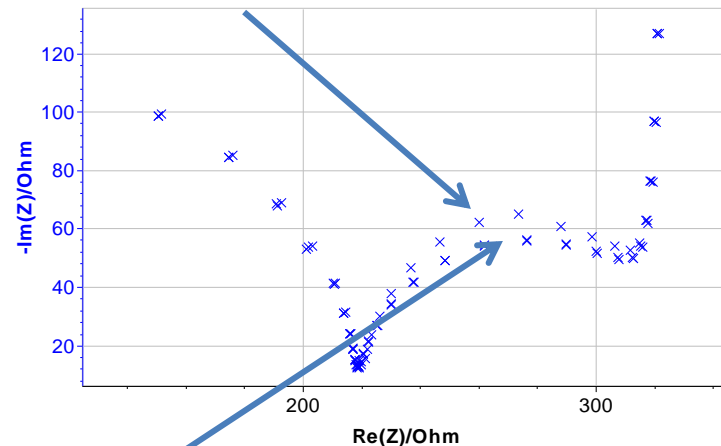


After a pulse of current

Without drift correction

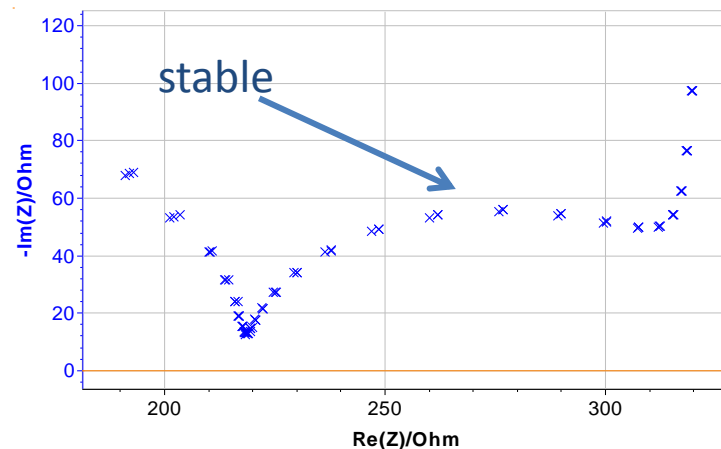
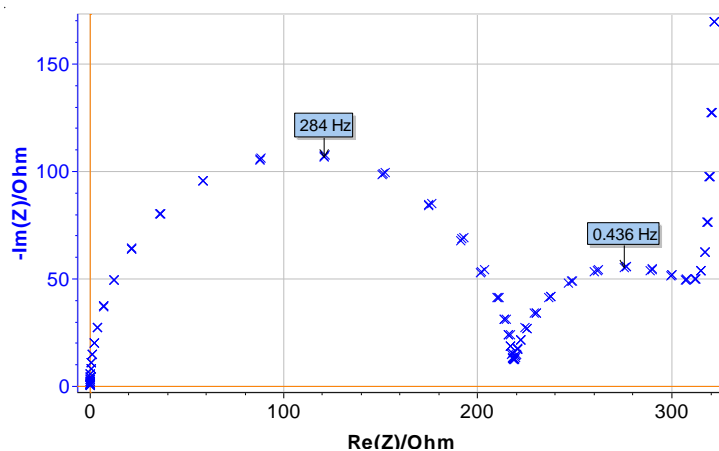


First EIS just after the current pulse is higher

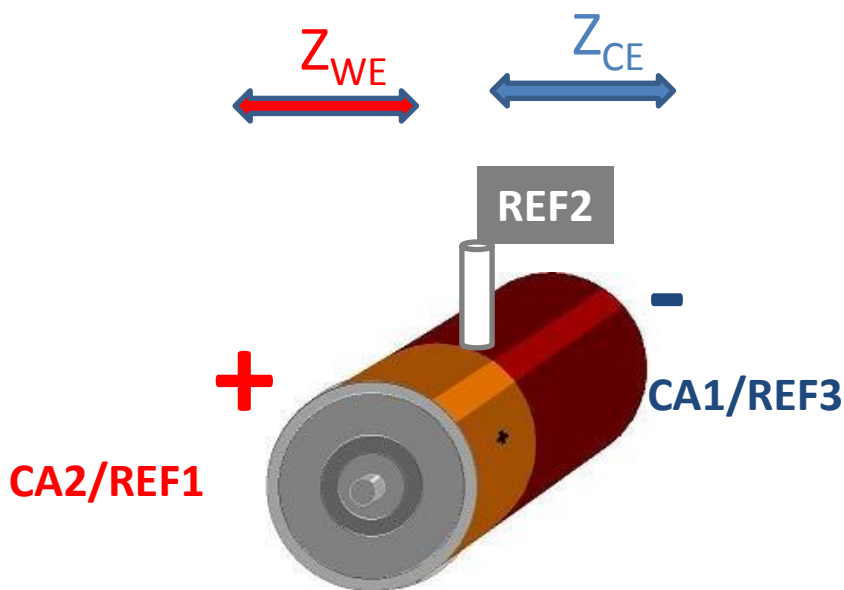


Two other EIS (done after) are stable

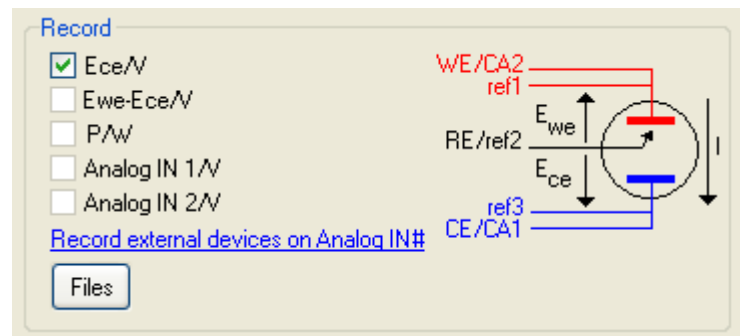
With drift correction



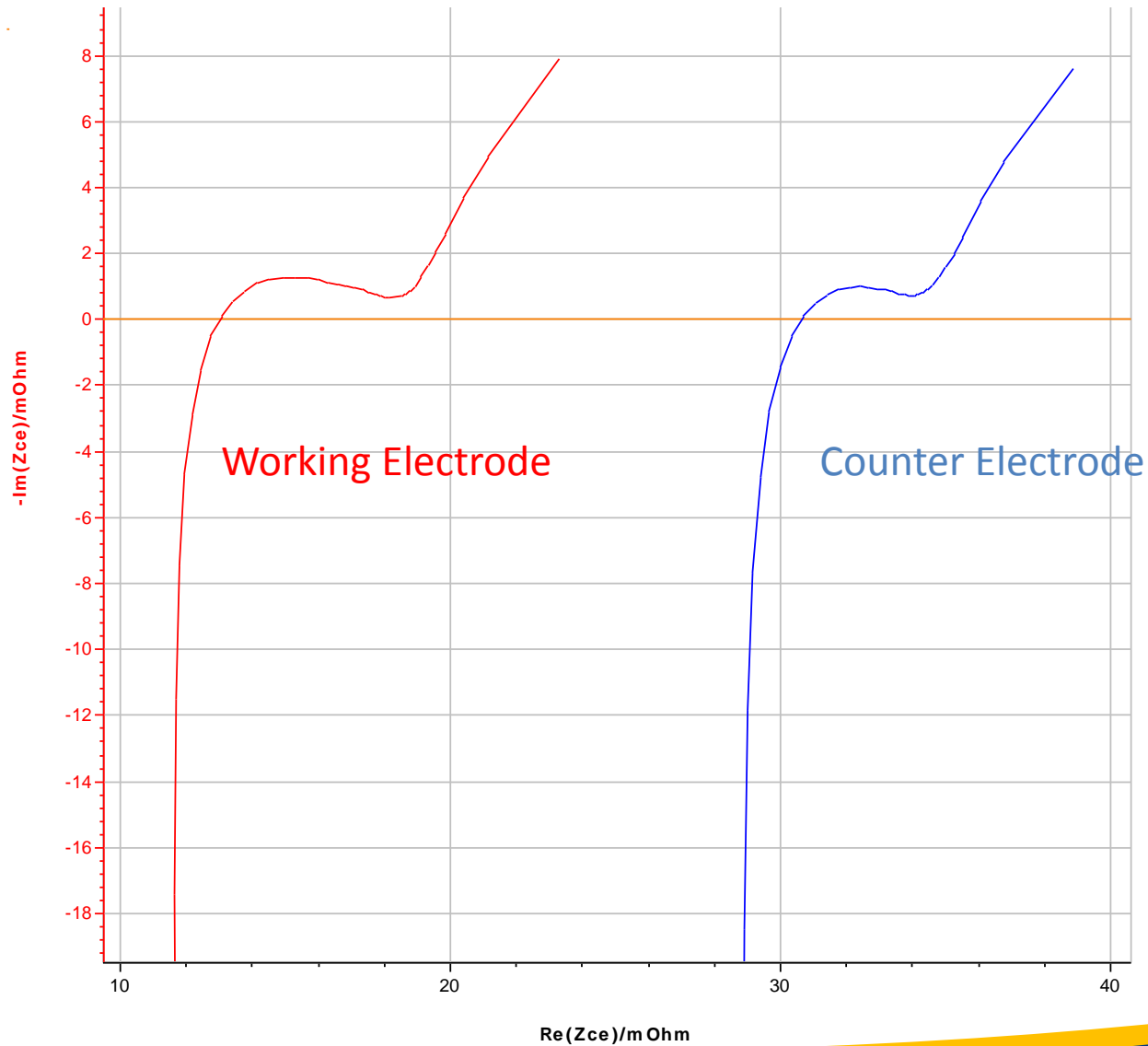
For this kind of measurement, a three-electrode setup is required.



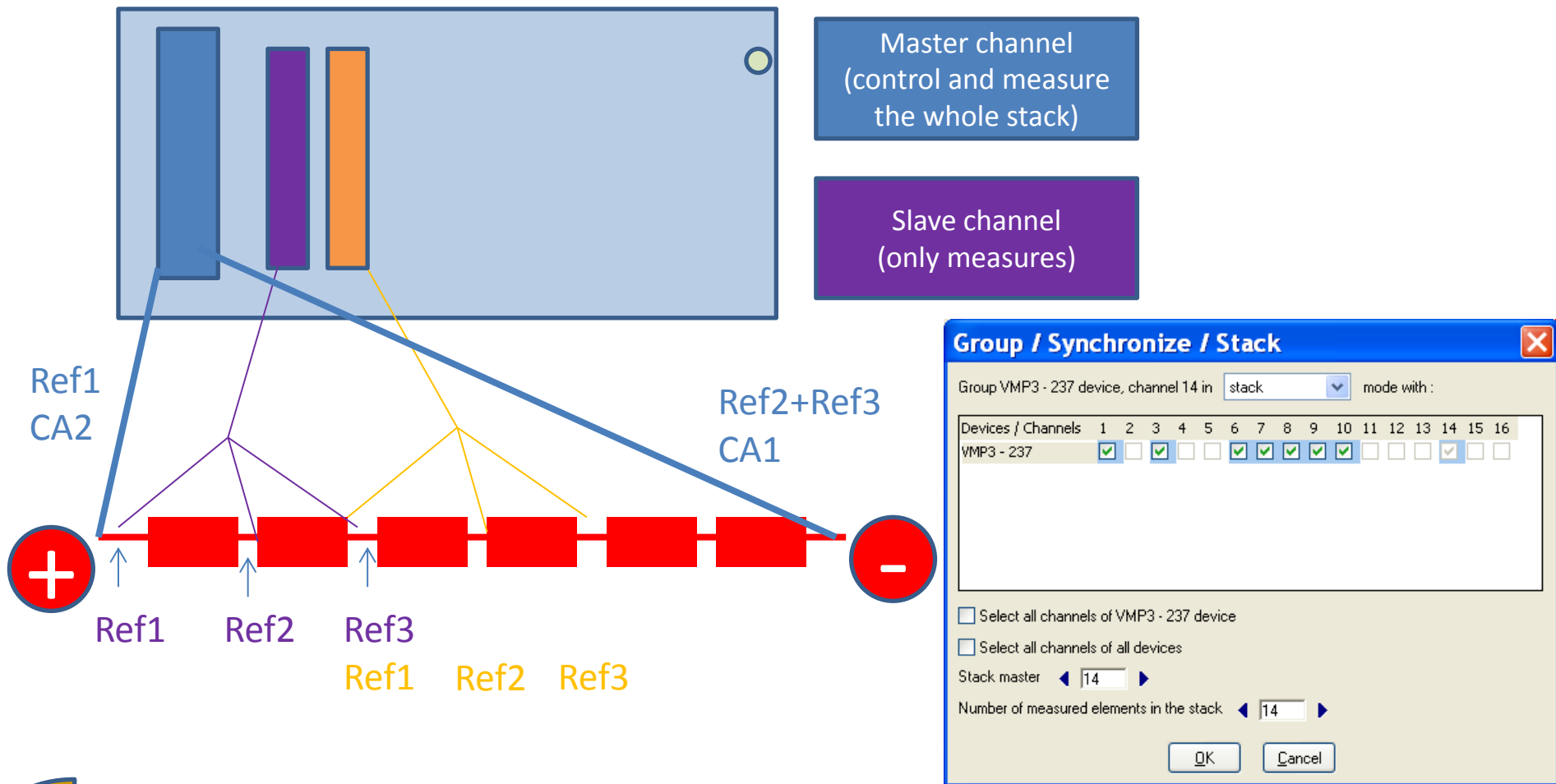
In « Cell Characteristics » tab:




Simultaneous and independent measurement on the two sides of a system. Battery, fuel cell, supercapacitor with a ref electrode.



difference is not due to the battery but to the connection



Master channel
(control and measure
the whole stack)

Slave channel
(only measures)

Group / Synchronize / Stack

Group VMP3 - 237 device, channel 14 in stack mode with :

Devices / Channels	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16
VMP3 - 237	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>

Select all channels of VMP3 - 237 device
 Select all channels of all devices

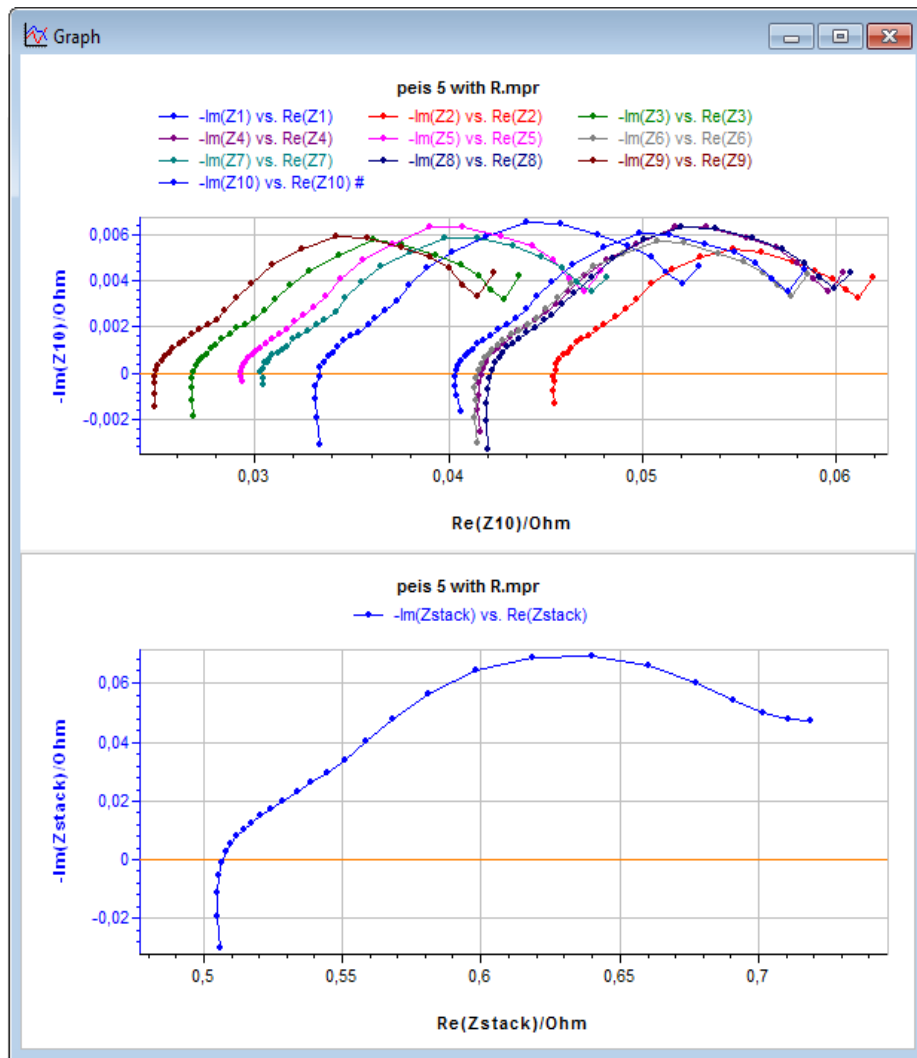
Stack master ◀ 14 ▶

Number of measured elements in the stack ◀ 14 ▶

OK Cancel

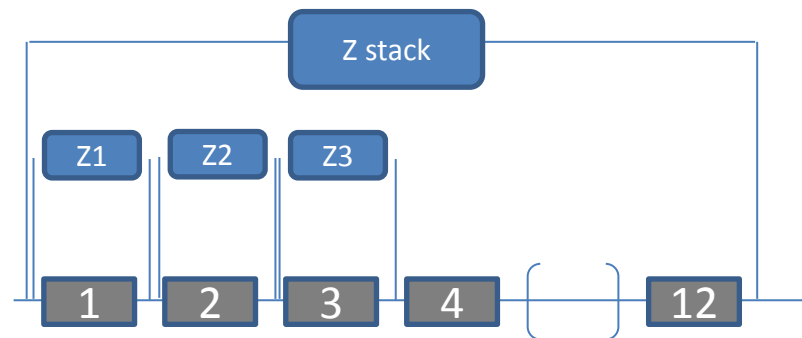


Simultaneously measurement on a whole stack and the behavior follow up of each cell.
 Battery, fuel cell, supercapacitor with a ref electrode.



- Stack of 12 elements

- Impedance of the stack (Z_{stack}) is the sum of the impedance of each element (Z_1, Z_2, \dots)

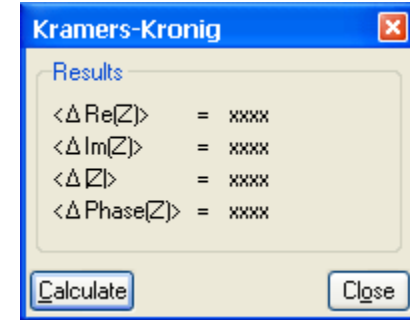


Some analysis tools of EC-Lab[®]

- Kramers-Kronig
- Zfit
- Mott-Schottky/capacity measurement

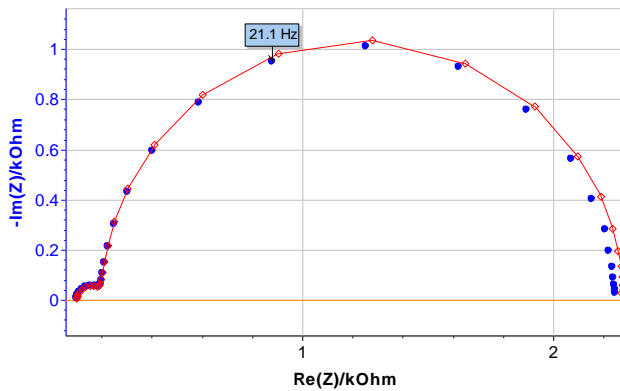
- There is a relationship between $\text{Re}(Z)$ and $\text{Im}(Z)$ when:
- causal, stable and linear time invariant system
 - when $f \rightarrow 0$ and $f \rightarrow \infty$

Checks the validity of the measurement

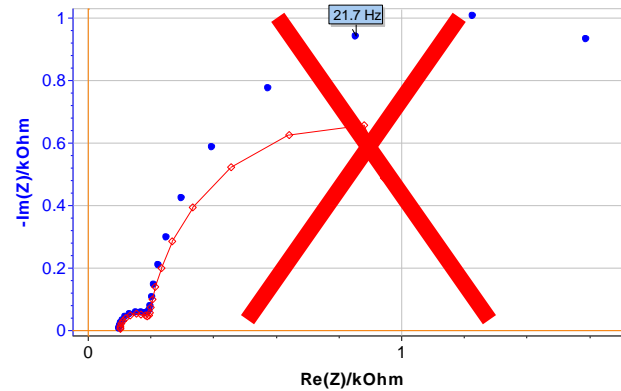


This works only for non-truncated plot.

Applicable



Non-applicable



2 Fit

Selection Results

Equivalent circuit

C1

param.	sel.	sign	value	unit	dev.
C1	<input checked="" type="checkbox"/>	+/-	1e-6	F	xxxx
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				
	<input type="checkbox"/>				

Calculate

Fit

Select: current cycle(s)

Method: Randomize + Simplex

Randomize: first cycle only

Stop randomize on: 10000 iterations

Stop fit on: 5000 iterations

Weight:

χ^2	xxxx	χ^2/\sqrt{N}	xxxx
Iterations	xxxx	Cycle	xxxx

Minimize PseudoC Copy Save Close

Equivalent Circuit Edition

Circuit 2/2

R1+C2/R2+W3

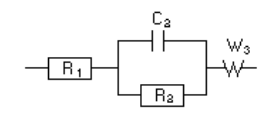
Display Circuits With:

- 4 Element(s)
- R,C,W Element(s)
- All Circuits

R1+C2/(R2+W2)
R1+C2/R2+W3

Add Modify Remove Move Up Move Down

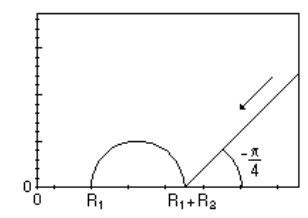
Description



Impedance

$$Z(f) = R_1 + \frac{R_2}{1 + i2\pi f R_2 C_2} + \frac{\sqrt{2} \sigma_3}{\sqrt{i2\pi f}}$$

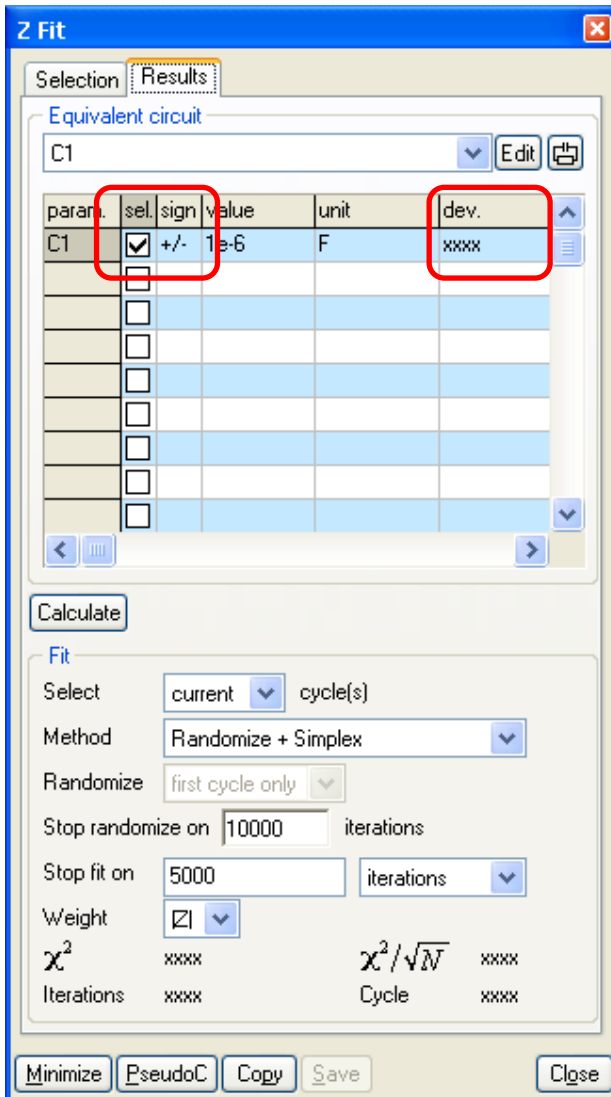
Nyquist Diagram (-Im(Z) vs. Re(Z))



OK Cancel

9 elements:

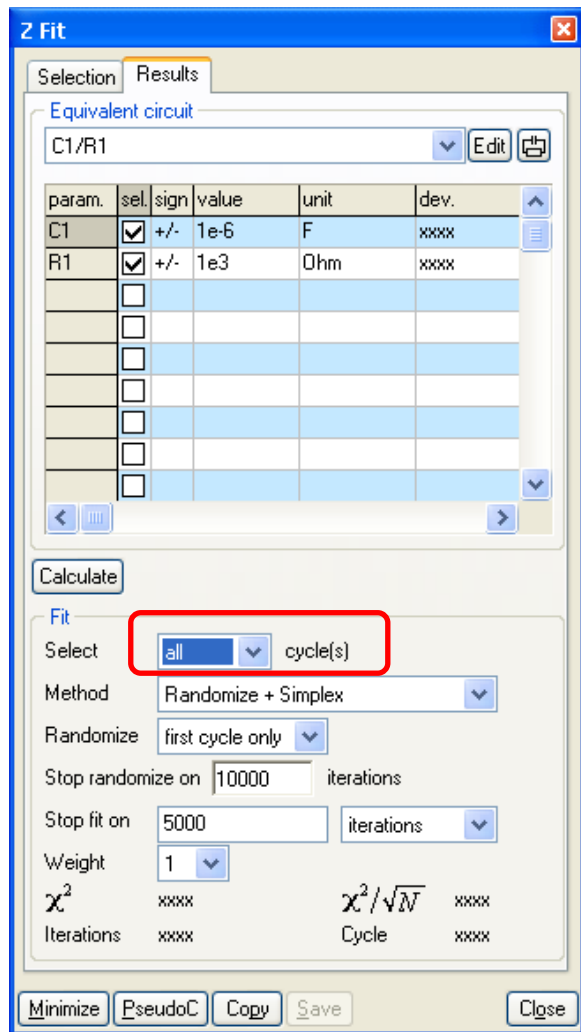
- R: resistor,
- L: self/inductor,
- C: capacitor,
- Q: constant Phase Element (CPE),
- W: Warburg Element simulating the semi-infinite diffusion,
- W_d : Warburg Diffusion Element simulating the convective diffusion,
- M: restricted Linear Diffusion Element,
- G: Gerischer Element.



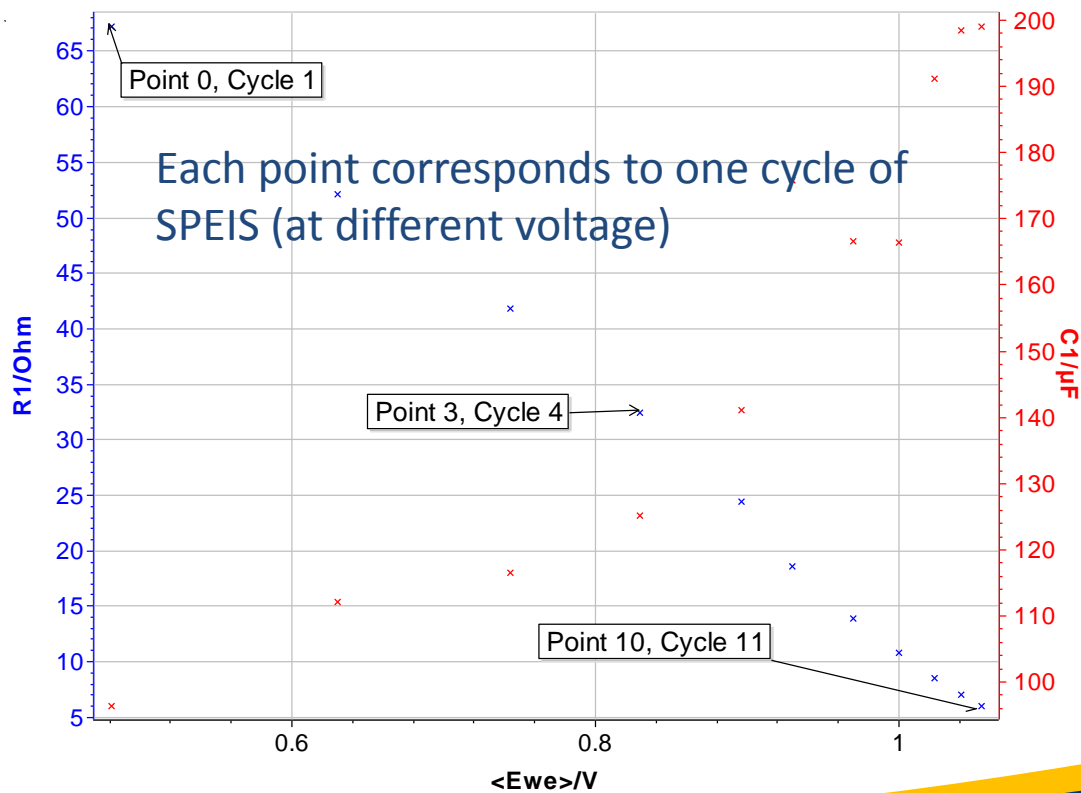
Sel: if this parameter is checked the corresponding value will be used in the fit as defined value (non minimized)

Sign: selection of the sign allowed for the parameter. + and/or -.

Dev: confidence interval (like a standard deviation).

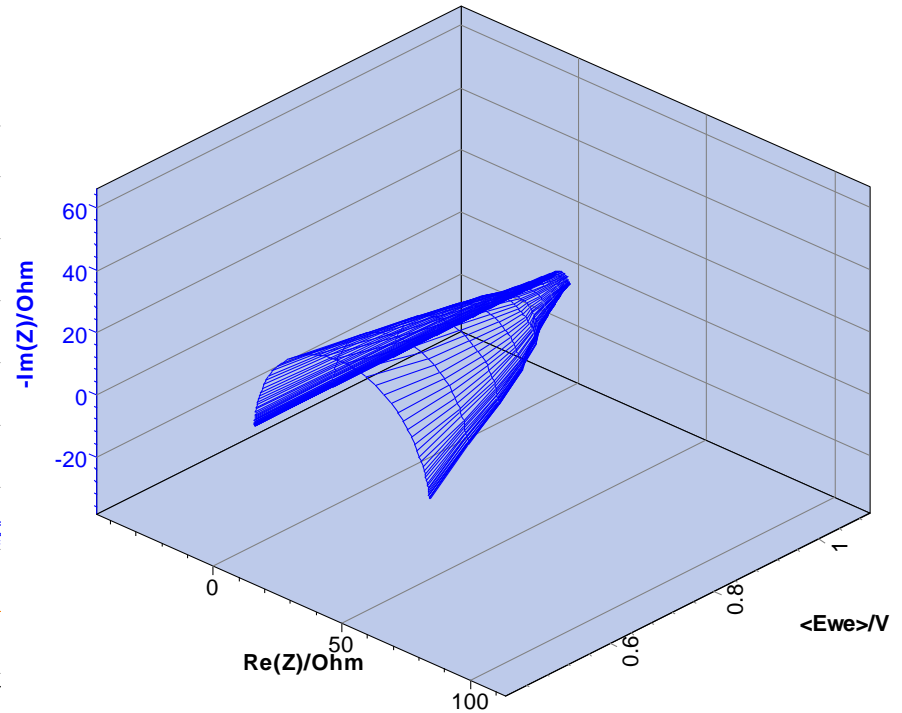
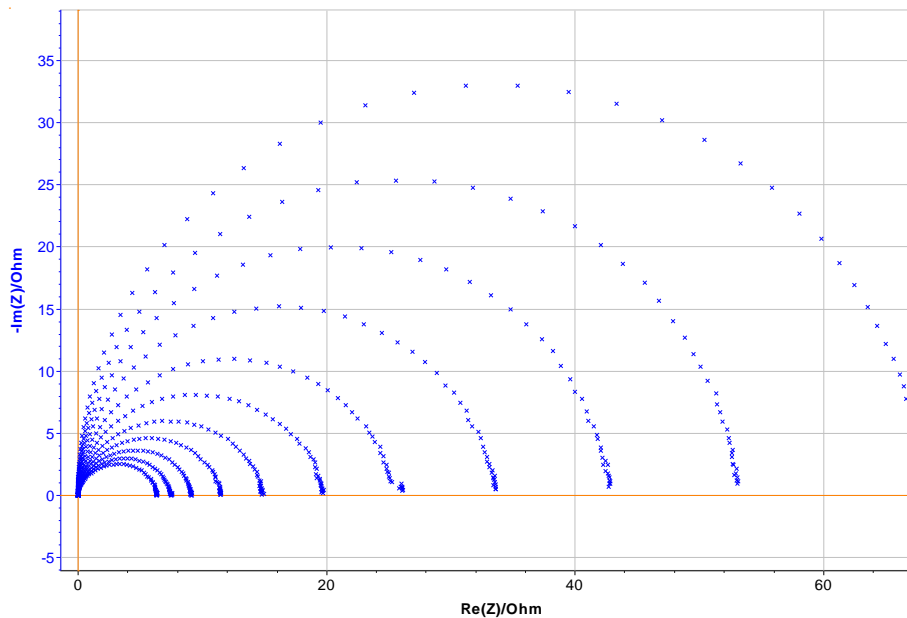


Cycle: allow to fit one cycle or several cycles successively and allow one to follow the changes of the values with the cycles



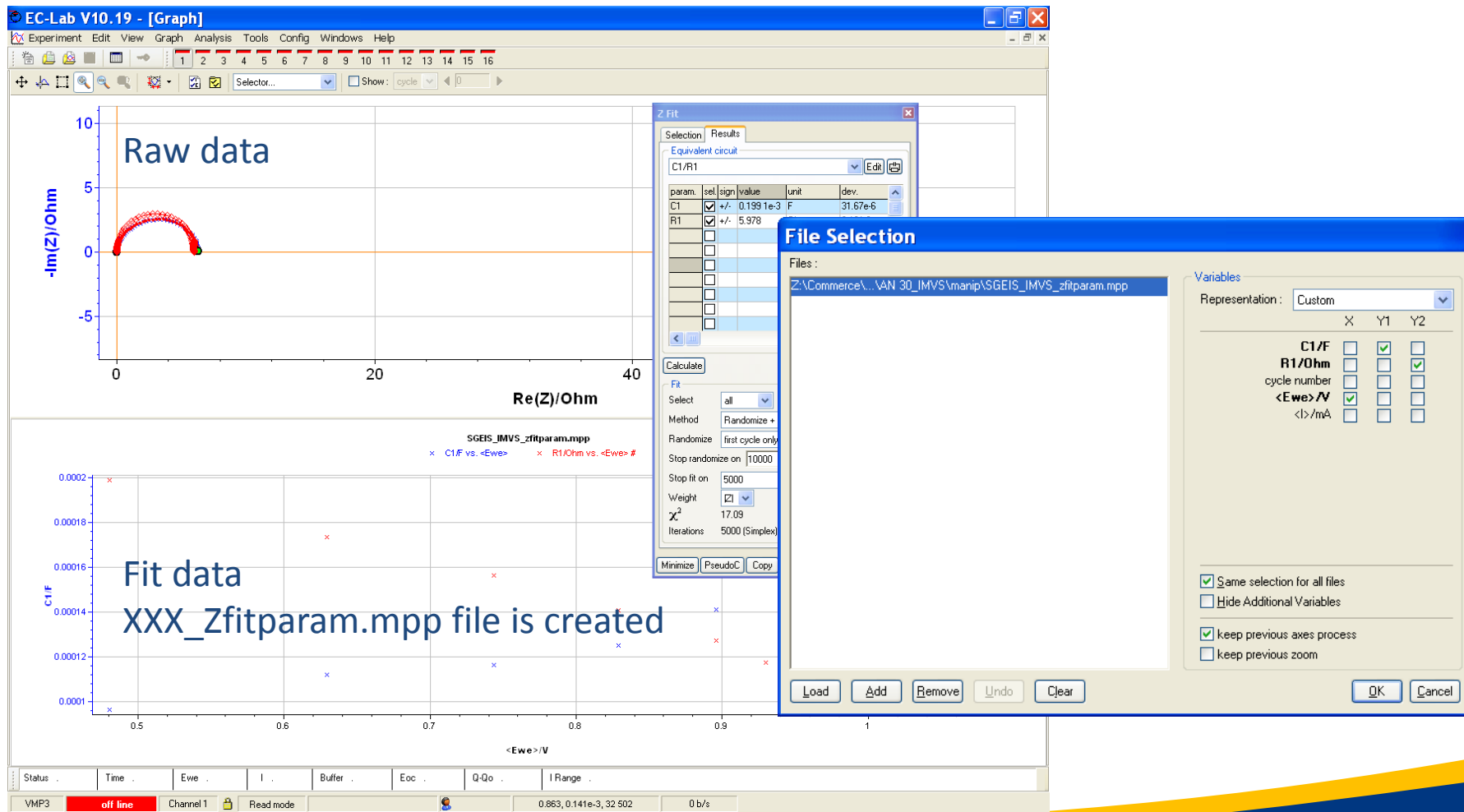
Each point corresponds to one cycle of SPEIS (at different voltage)

- Fit on several cycles



Follow up of the element values variations with time/potential/current..

- Fit on several cycles



Raw data

Fit data
XXX_Zfitparam.mpp file is created

Z Fit

Selection Results

Equivalent circuit

C1/R1

param.	sel	sign	value	unit	dev.
C1	<input checked="" type="checkbox"/>	+/-	0.1991e-3	F	31.67e-6
R1	<input checked="" type="checkbox"/>	+/-	5.978		

File Selection

Files :

Z:\Commerce\...\VAN_30_IMVS\manip\SGEIS_IMVS_zfitparam.mpp

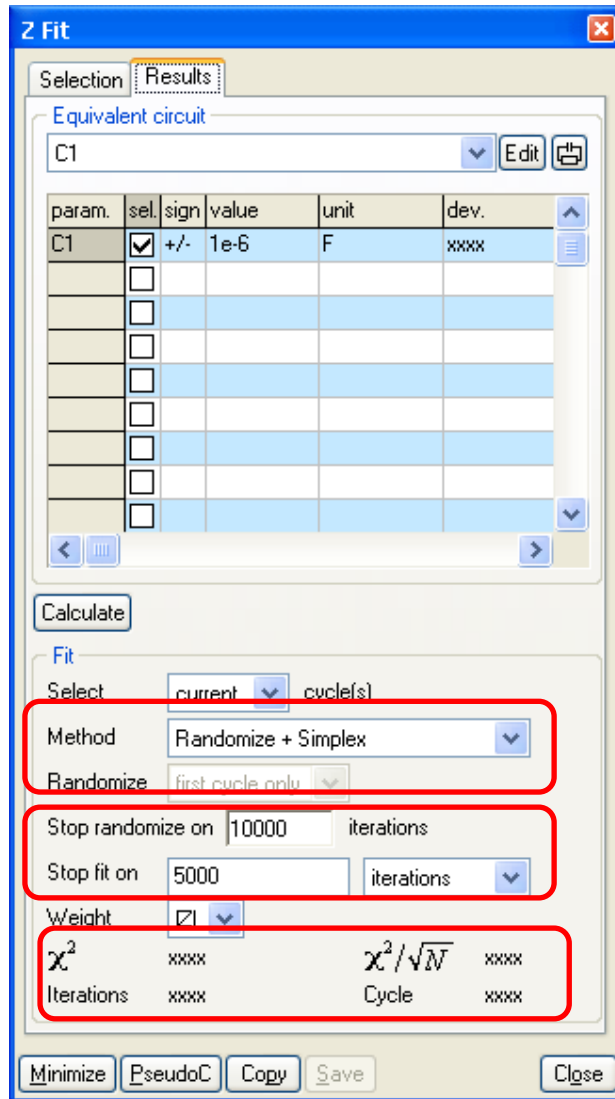
Variables

Representation : Custom

	X	Y1	Y2
C1/F	<input type="checkbox"/>	<input checked="" type="checkbox"/>	<input type="checkbox"/>
R1/Ohm	<input type="checkbox"/>	<input type="checkbox"/>	<input checked="" type="checkbox"/>
cycle number	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
<Ewe>V	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
<I>/mA	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>

Same selection for all files
 Hide Additional Variables
 keep previous axes process
 keep previous zoom

Buttons: Load, Add, Remove, Undo, Clear, OK, Cancel



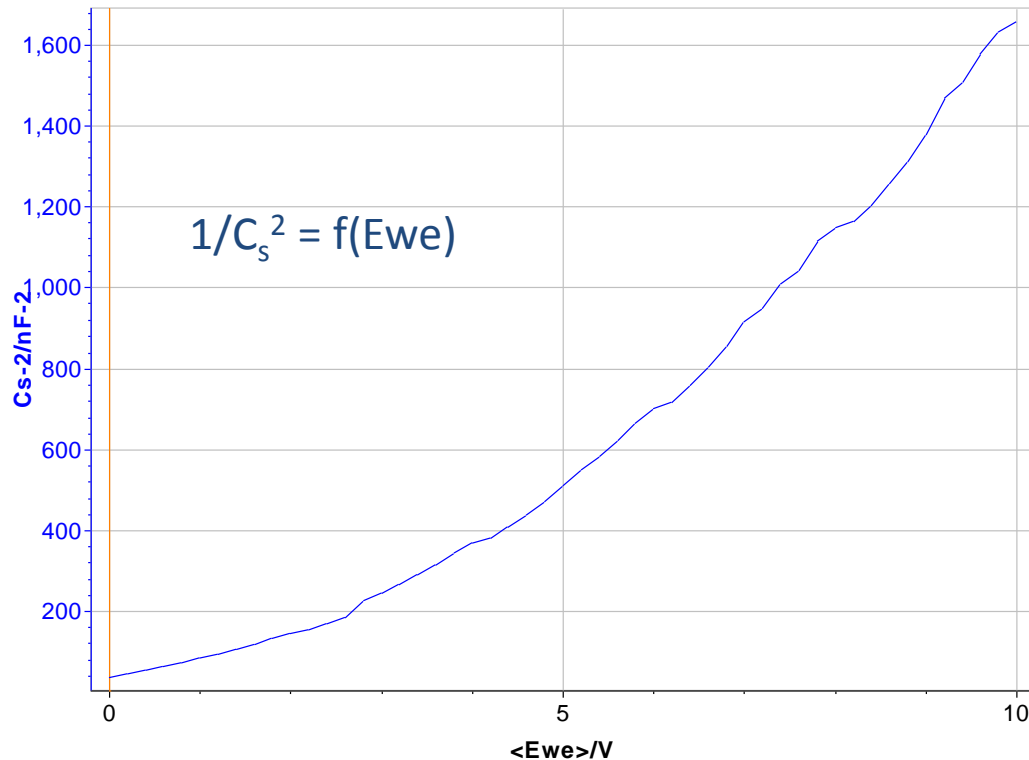
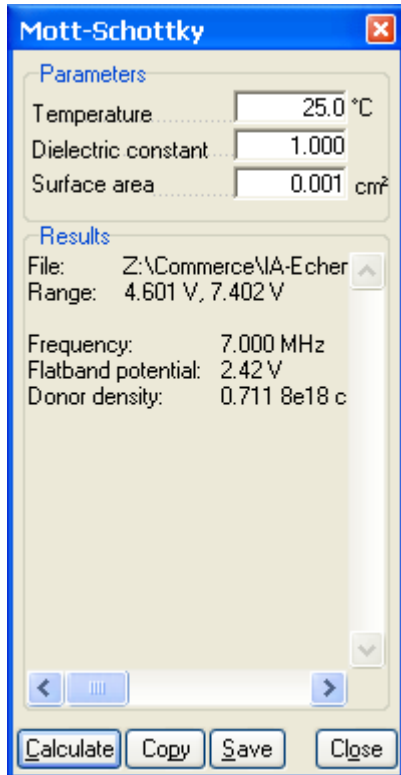
Method: Algorithm used for the fit

Iterations: Number of iteration

χ^2 quality of the fit. χ^2/N is weighted.

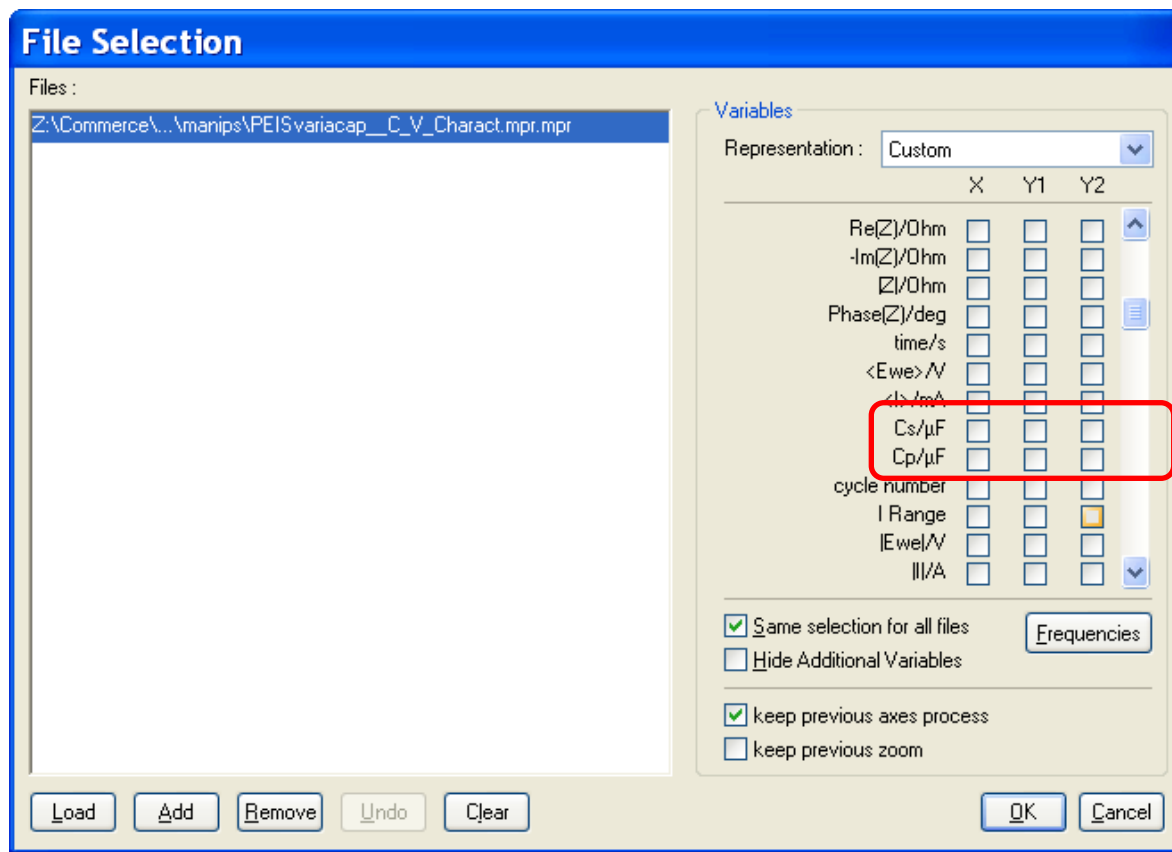
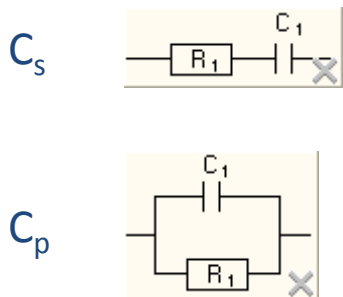
$$\frac{1}{C_{SC}^2} = \frac{2}{e\epsilon_0 N} \left(E - E_{FB} - \frac{kT}{e} \right)$$

C_{sc} is the capacitance of the space charge region,
 ϵ is the dielectric constant of the semiconductor,
 ϵ_0 is the permittivity of free space,
 N is the donor density (electron donor concentration for an n-type semi-conductor or hole acceptor concentration for a p-type semi-conductor),
 E is the applied potential,
 E_{FB} is the flatband potential.



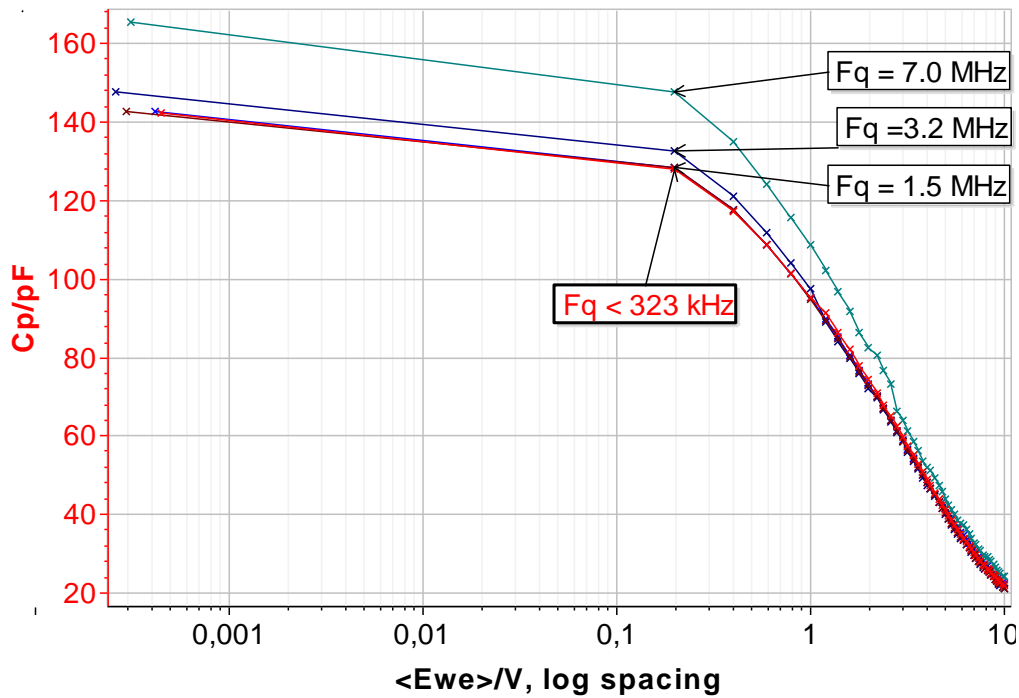
Determination of the flatband potential and the donor density
 For semi-conductor, such as PV cell, ...

If the equivalent circuit is modeled by R/C_p or $R+C_s$, the mpr file of the EIS techniques (PEIS, GEIS, SPEIS, SGEIS, PEISW) includes already the capacity value C_s and C_p .



This allows one to plot on-line (without Zfit), C_s or C_p versus voltage or time.

C vs Voltage at several frequencies



Feel free to visit our web site, some application notes or EIS handbook may be helpful for your applications:

<http://www.bio-logic.info/potentiostat/notesan.html>

Thank you for your attention

Lets move to the instruments